

EMV FILTERN UND ABBLOCKEN



EMV und HF-Technik
Eichstetter

*Verstehen, verbessern,
→ bestehen*

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2024-10-23

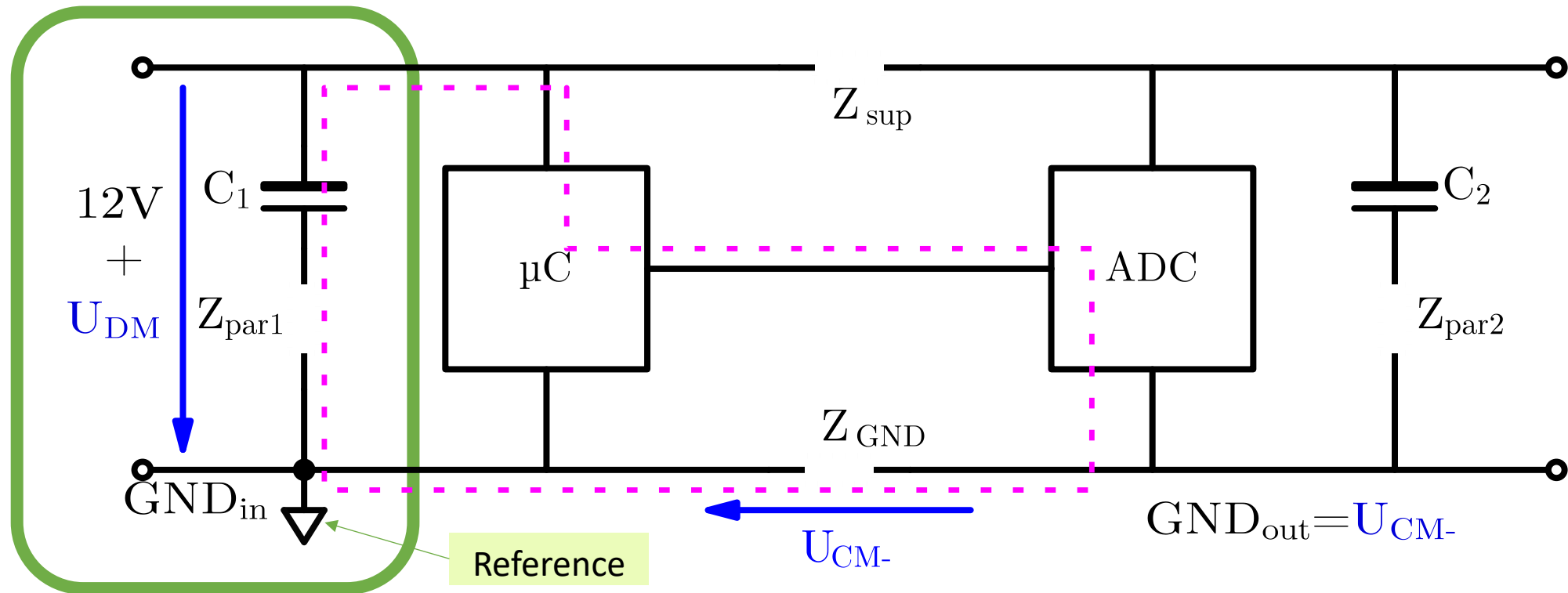
Übersicht



- 1 GLEICH- UND GEGENTAKTSTÖRUNG**
- 2 FILTERENTWURF MIT DER HF-TAPETE**
- 3 SNUBBER-DESIGN**
- 4 SCHIRMUNG**
- 5 ZUM EMV-SEMINAR ANMELDEN**

1. Gleich- und Gegentaktstörung

Heutiges Thema



AC

Spektralanalysator

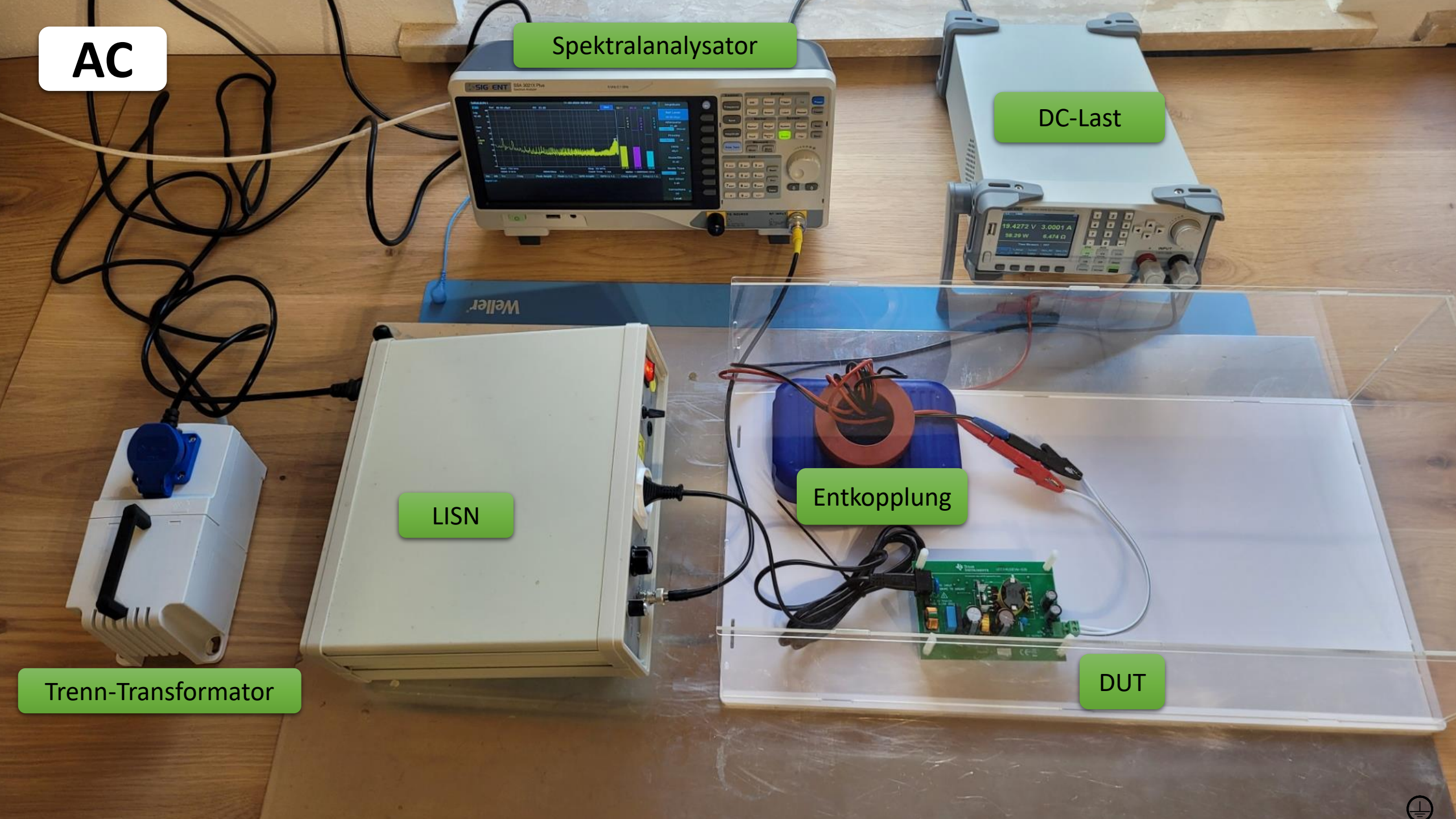
DC-Last

LISN

Entkopplung

Trenn-Transformator

DUT



DC

Spectrum analyser

DC-Load

CM/DM
Splitter

DM

CM

Supply

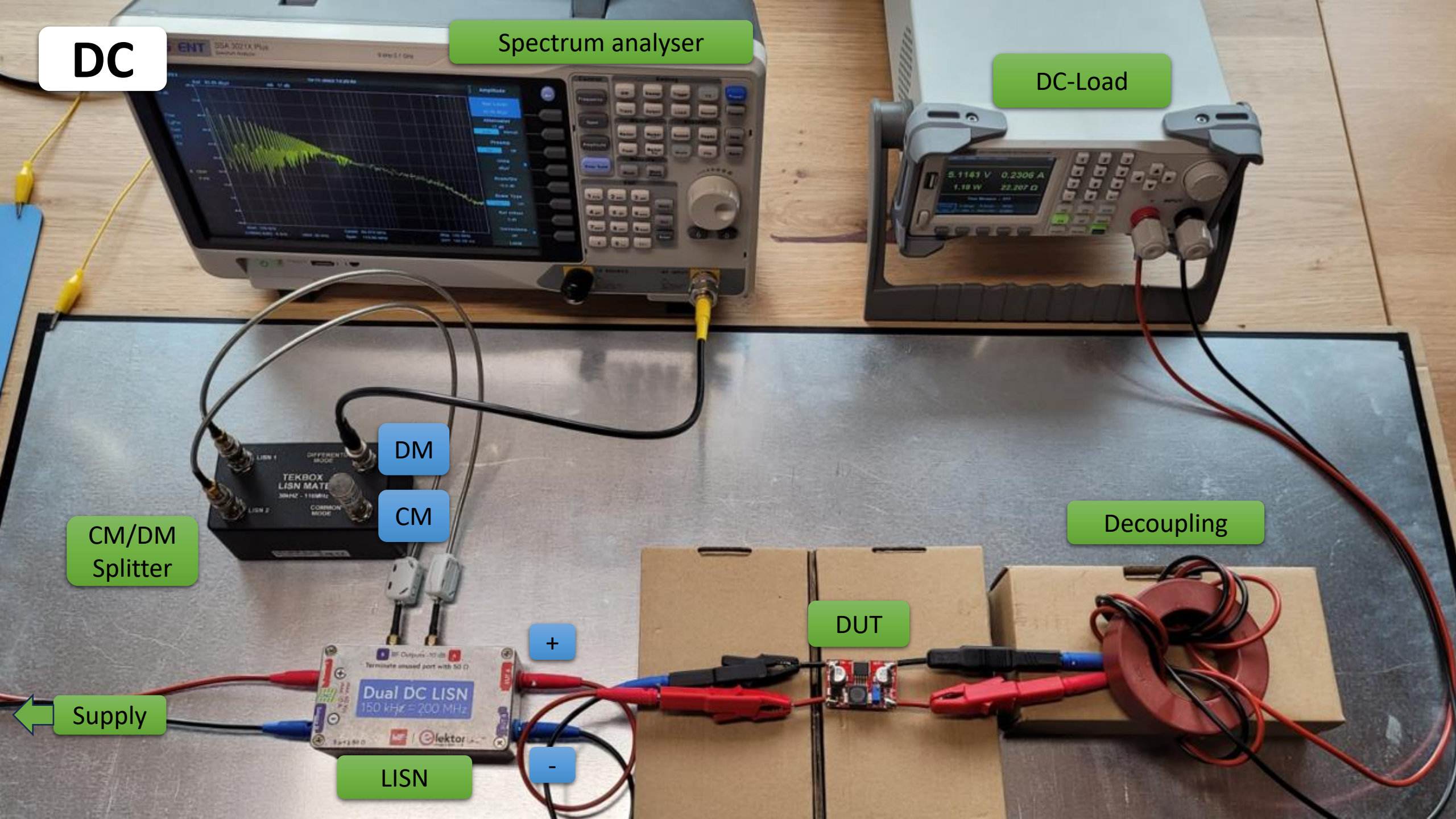
LISN

+

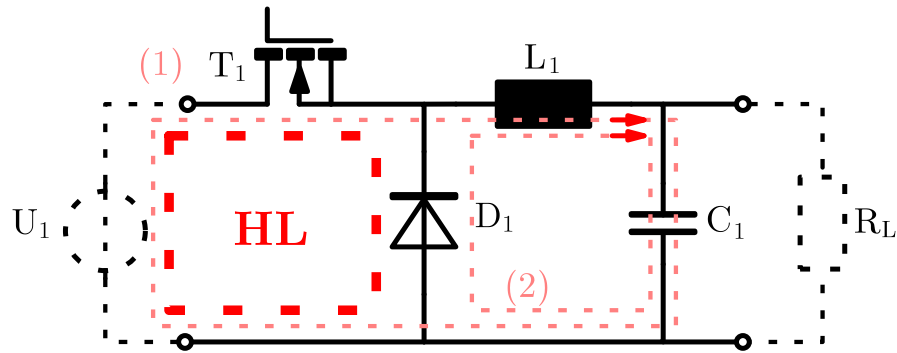
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DUT

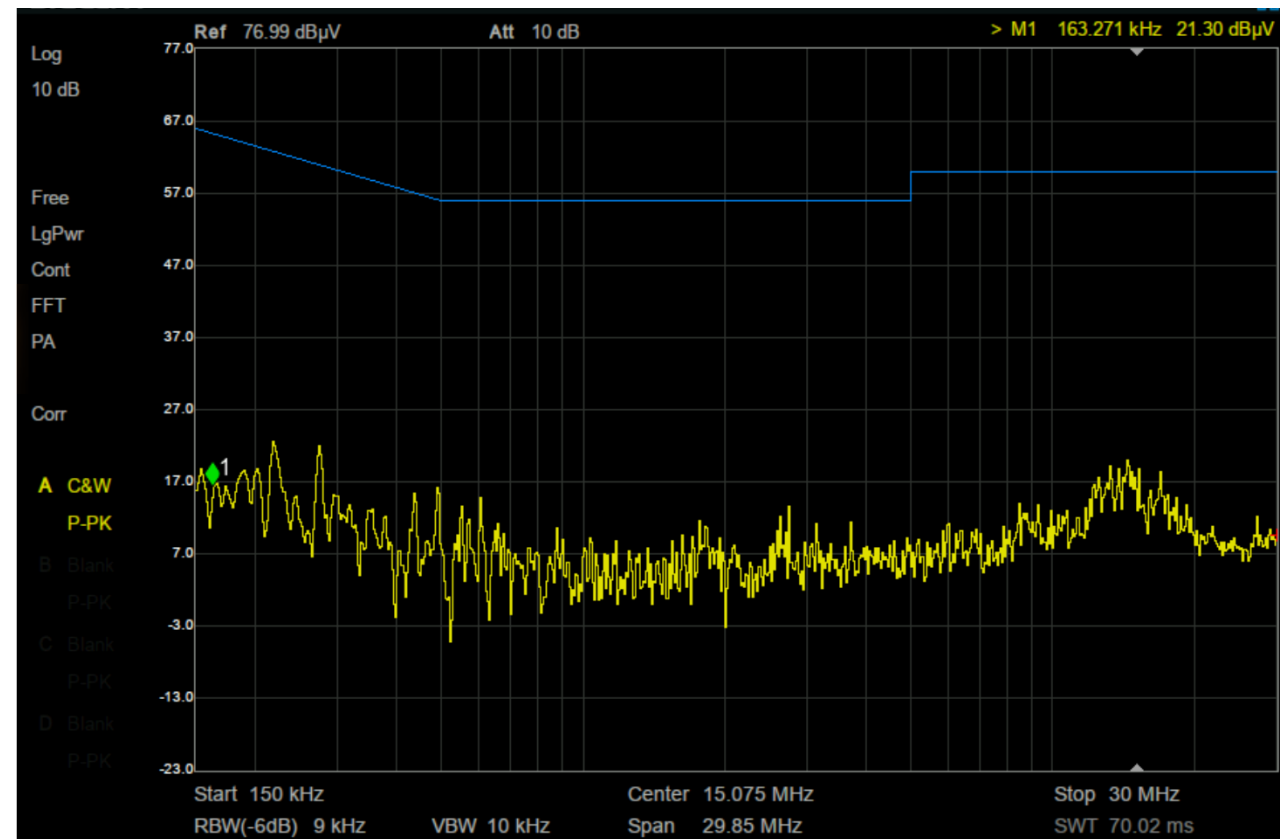
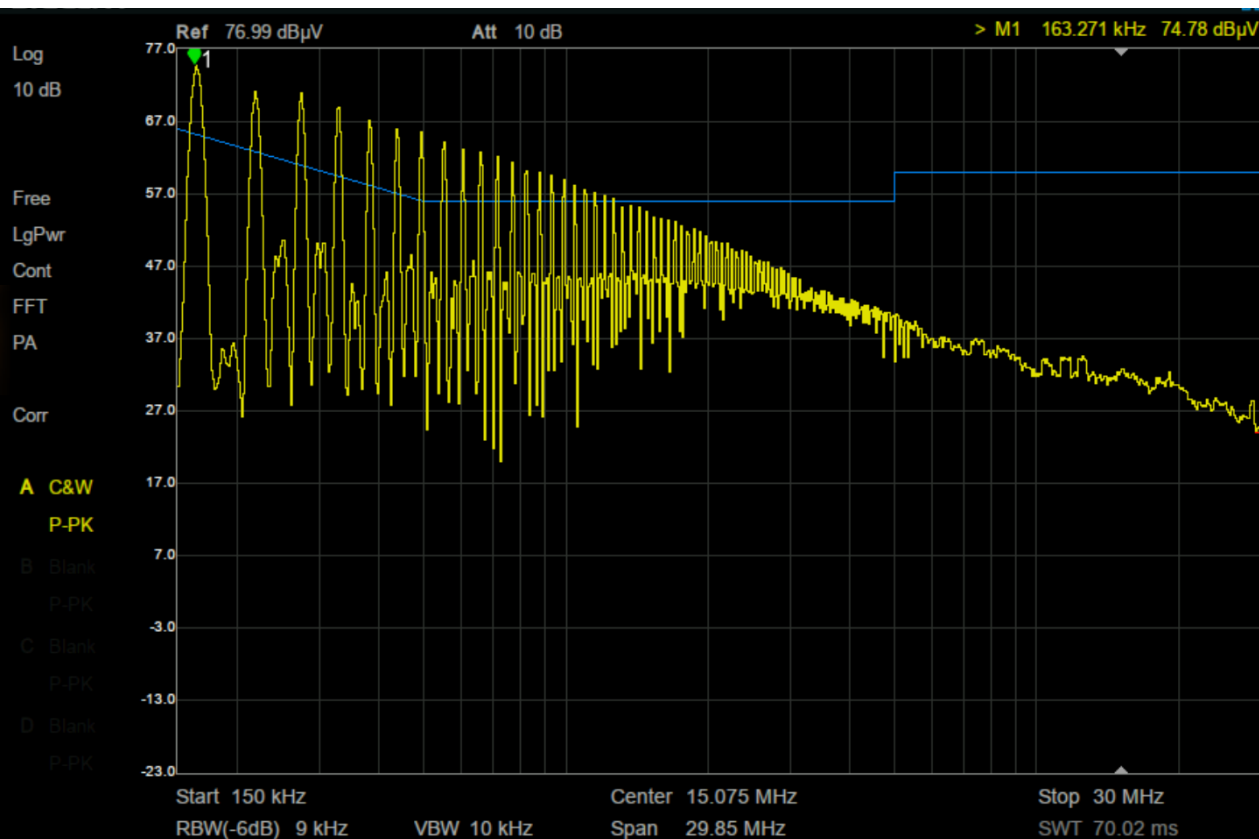
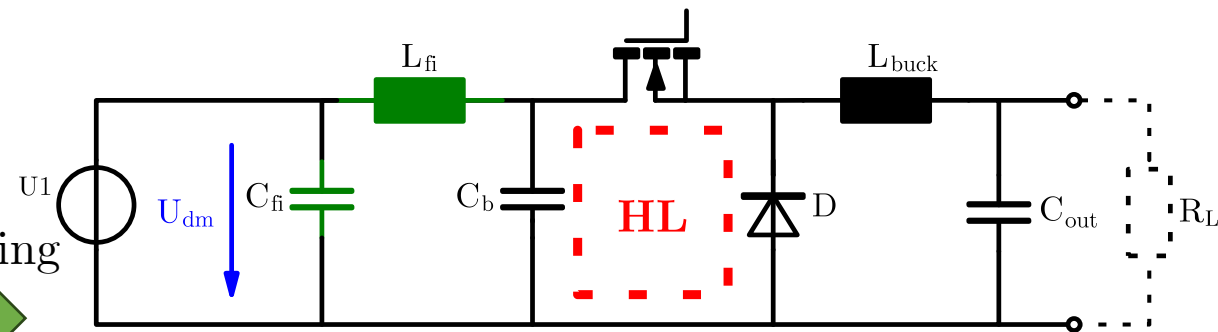
Decoupling

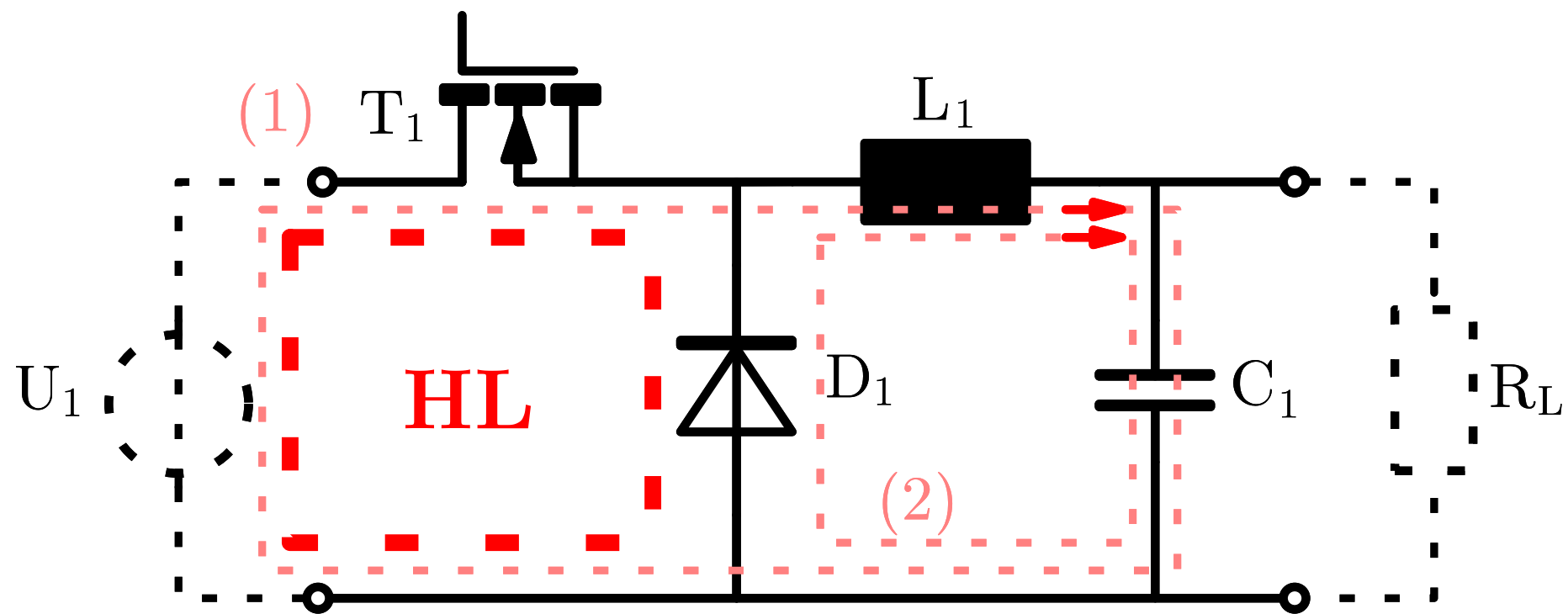


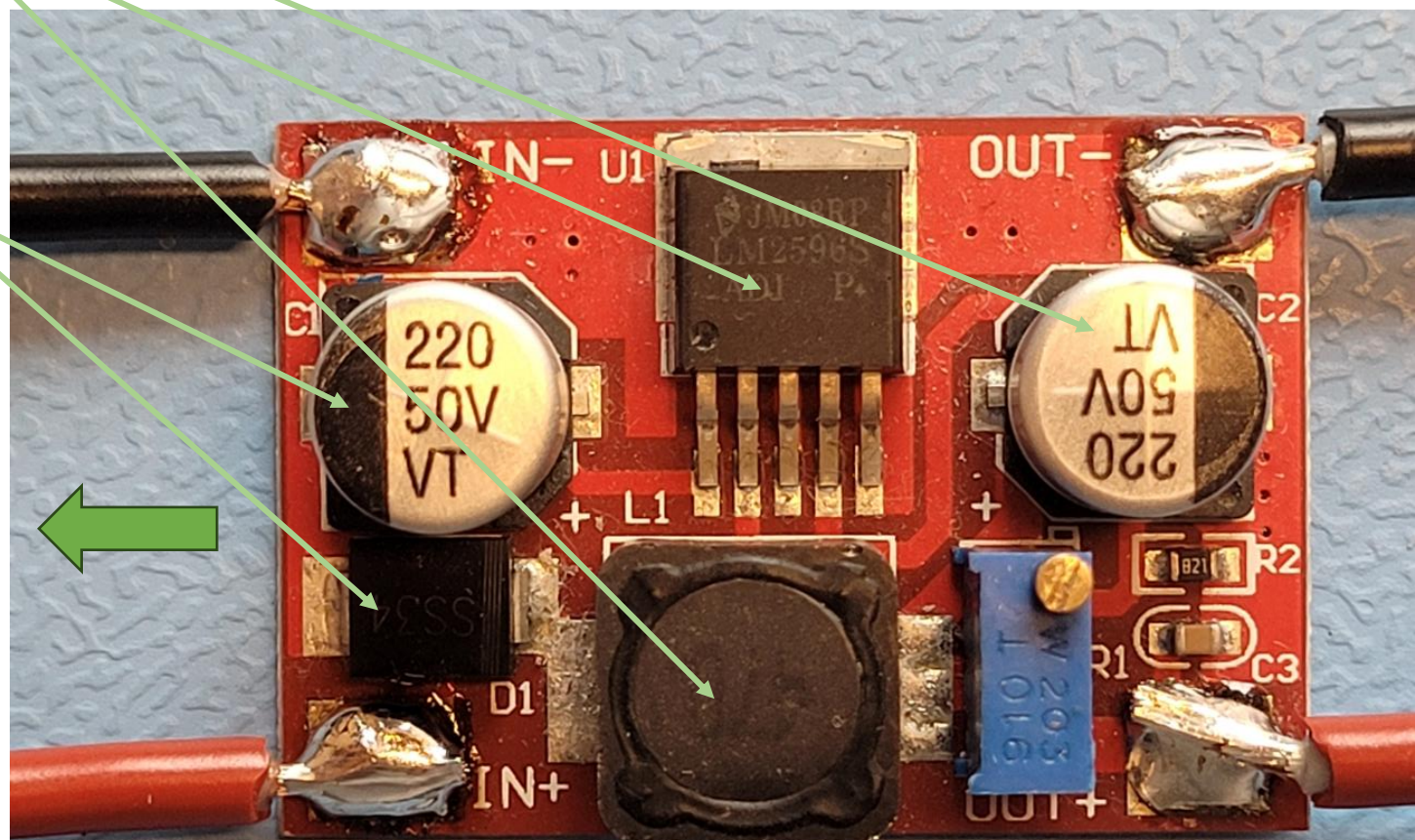
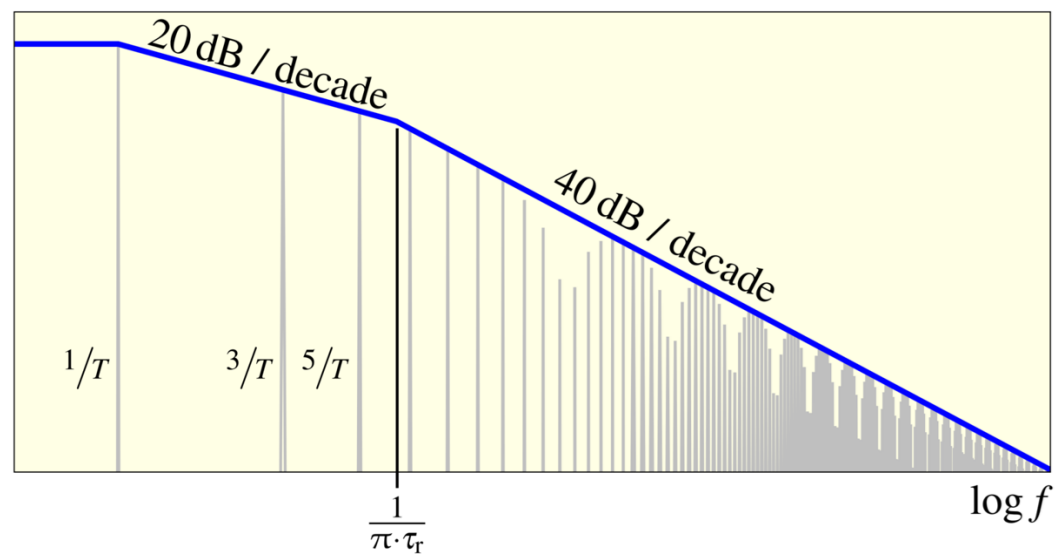
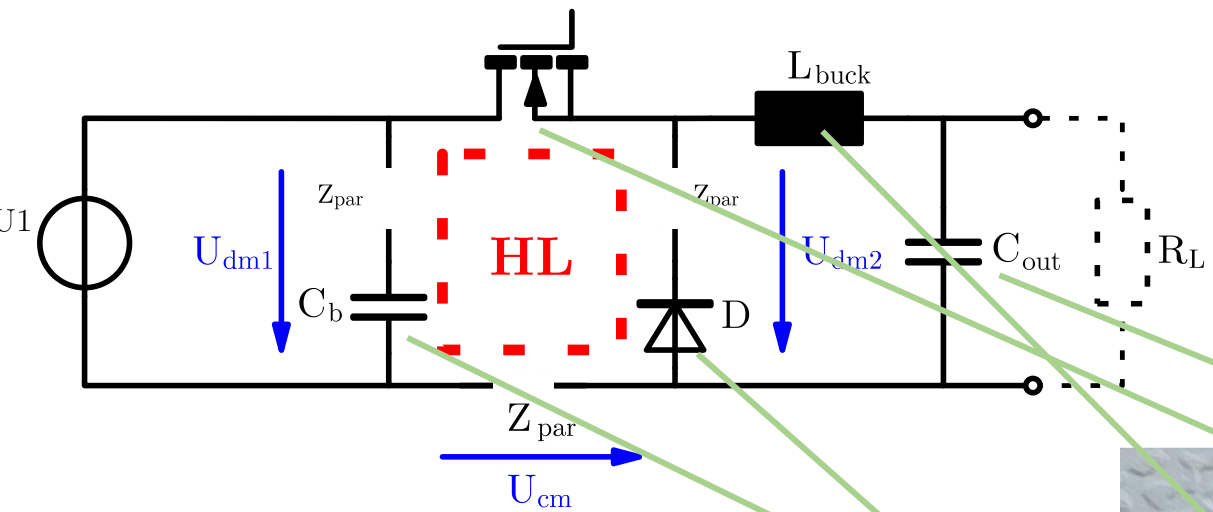
2 Filterentwurf mit der HF-Tapete

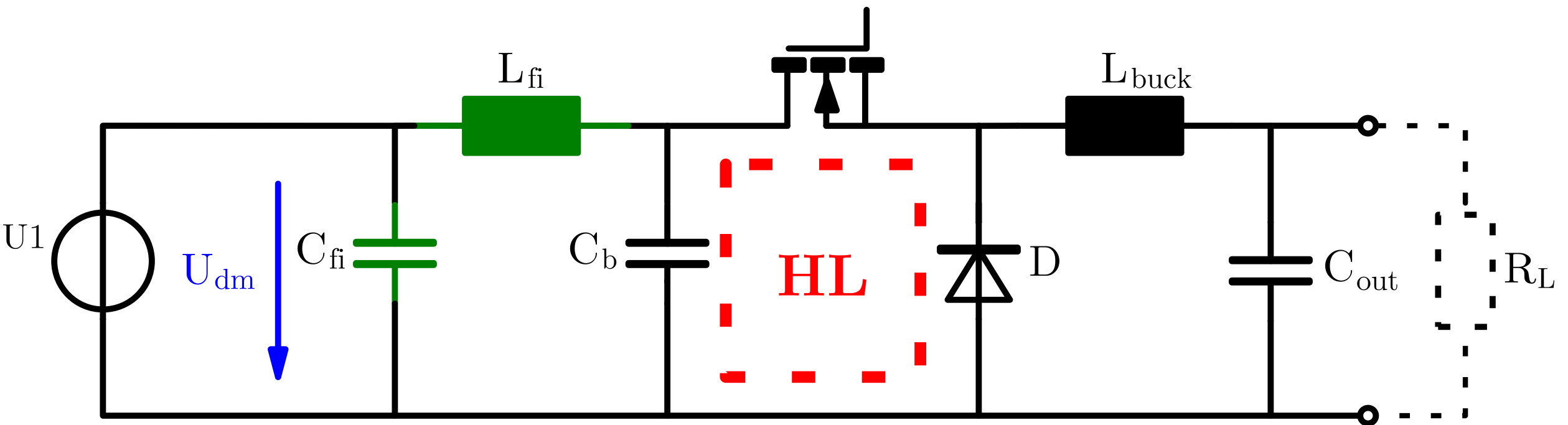
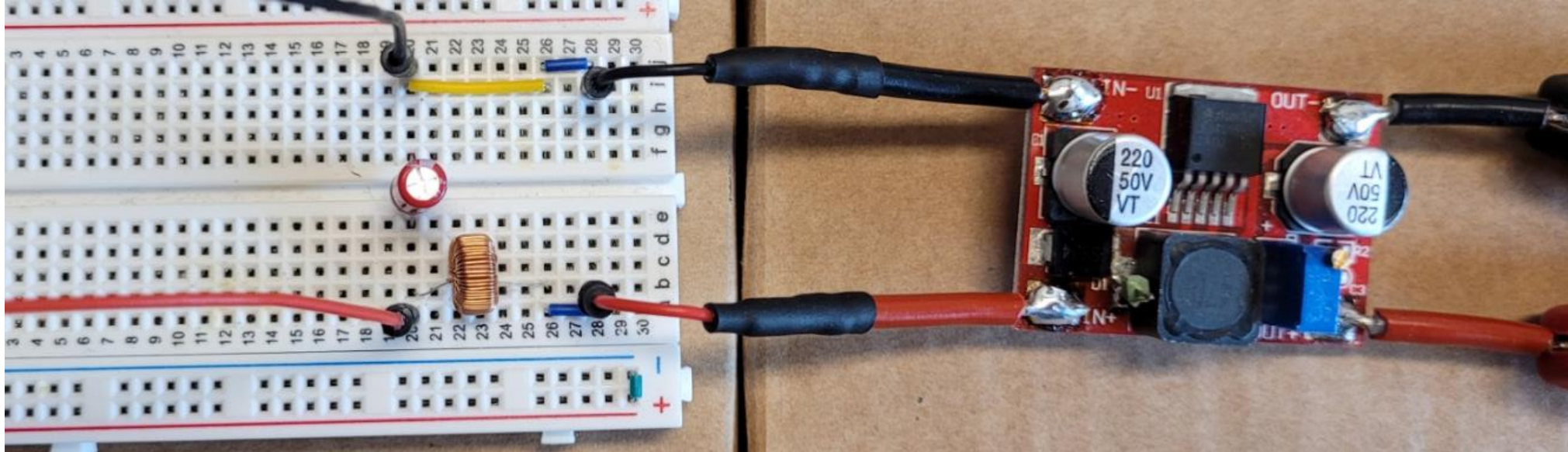


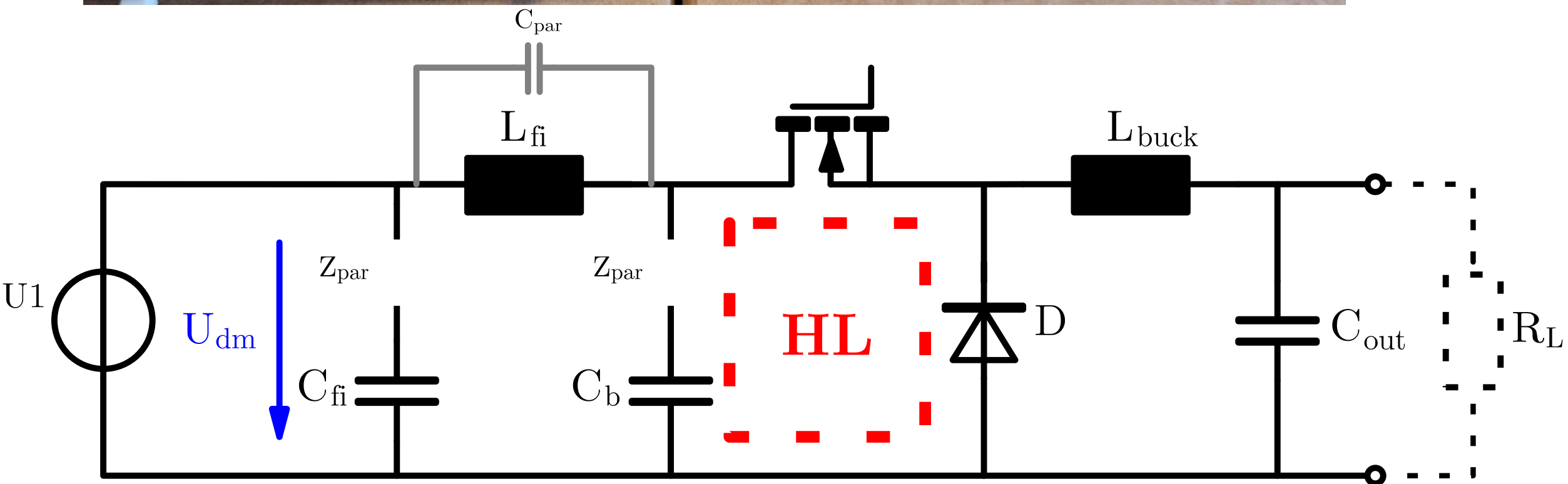
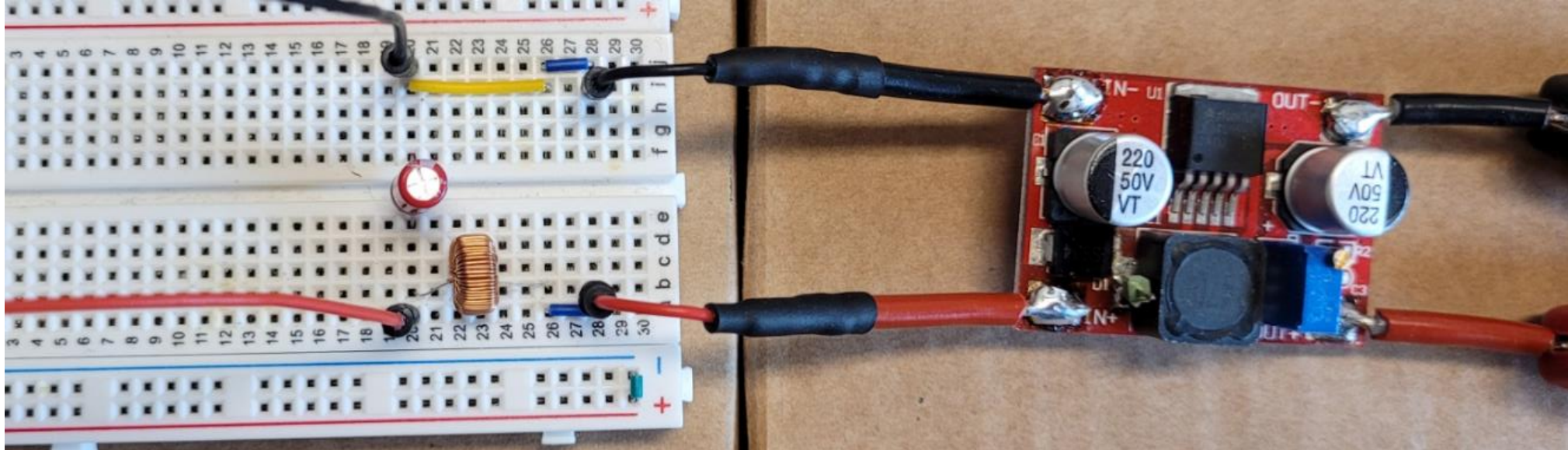
DM-filtering





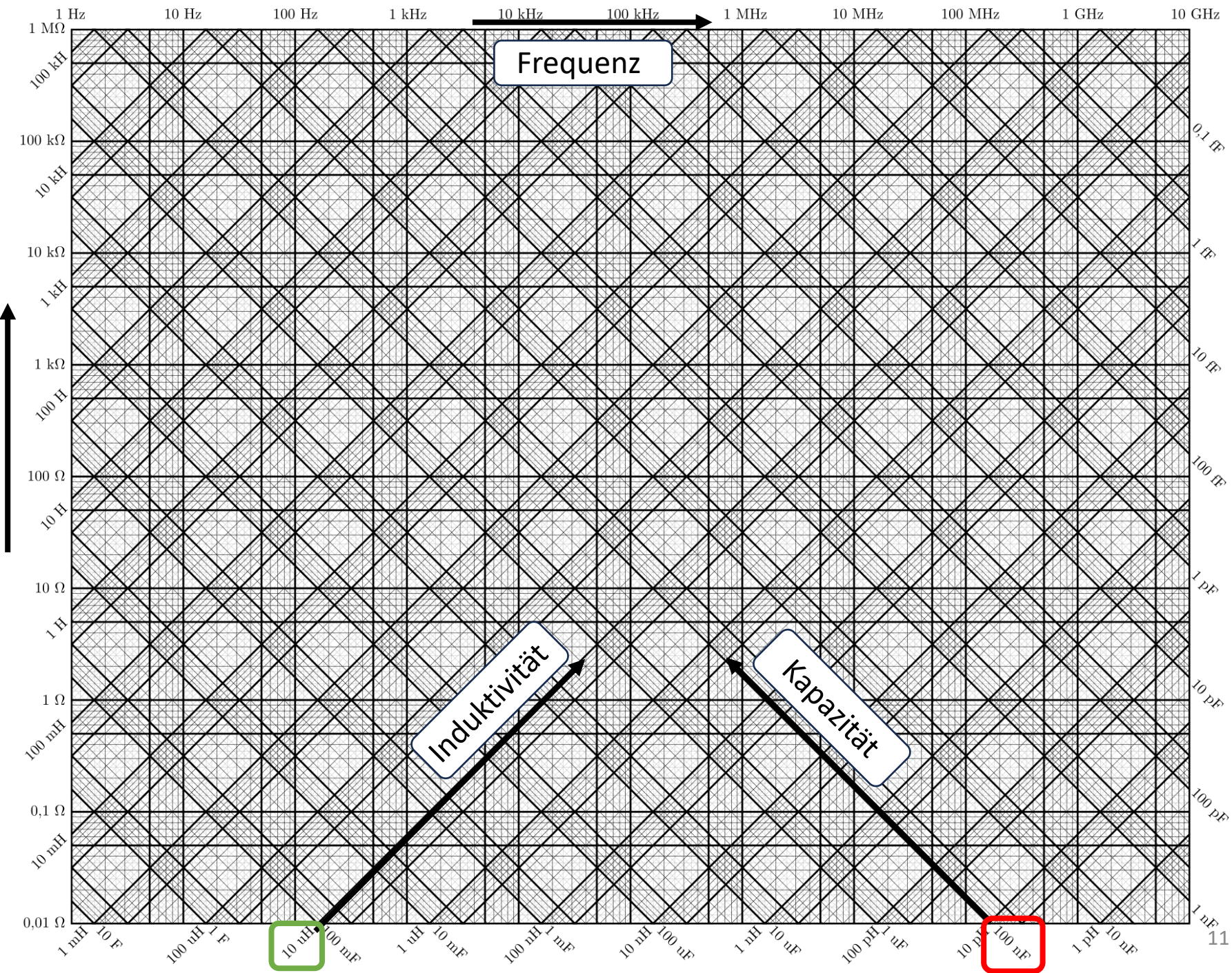




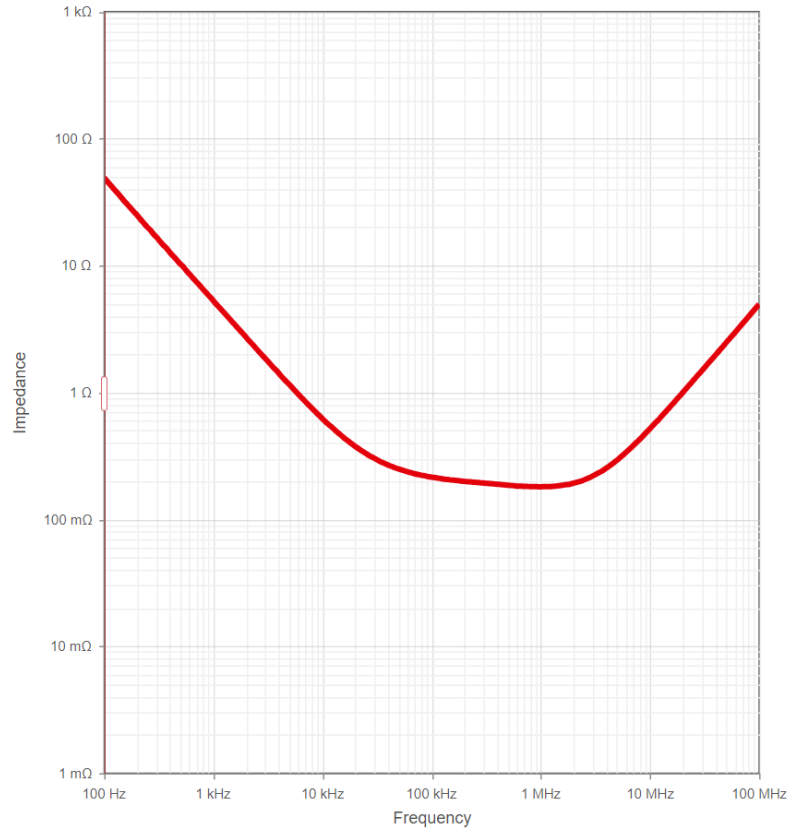


HF-Tapete

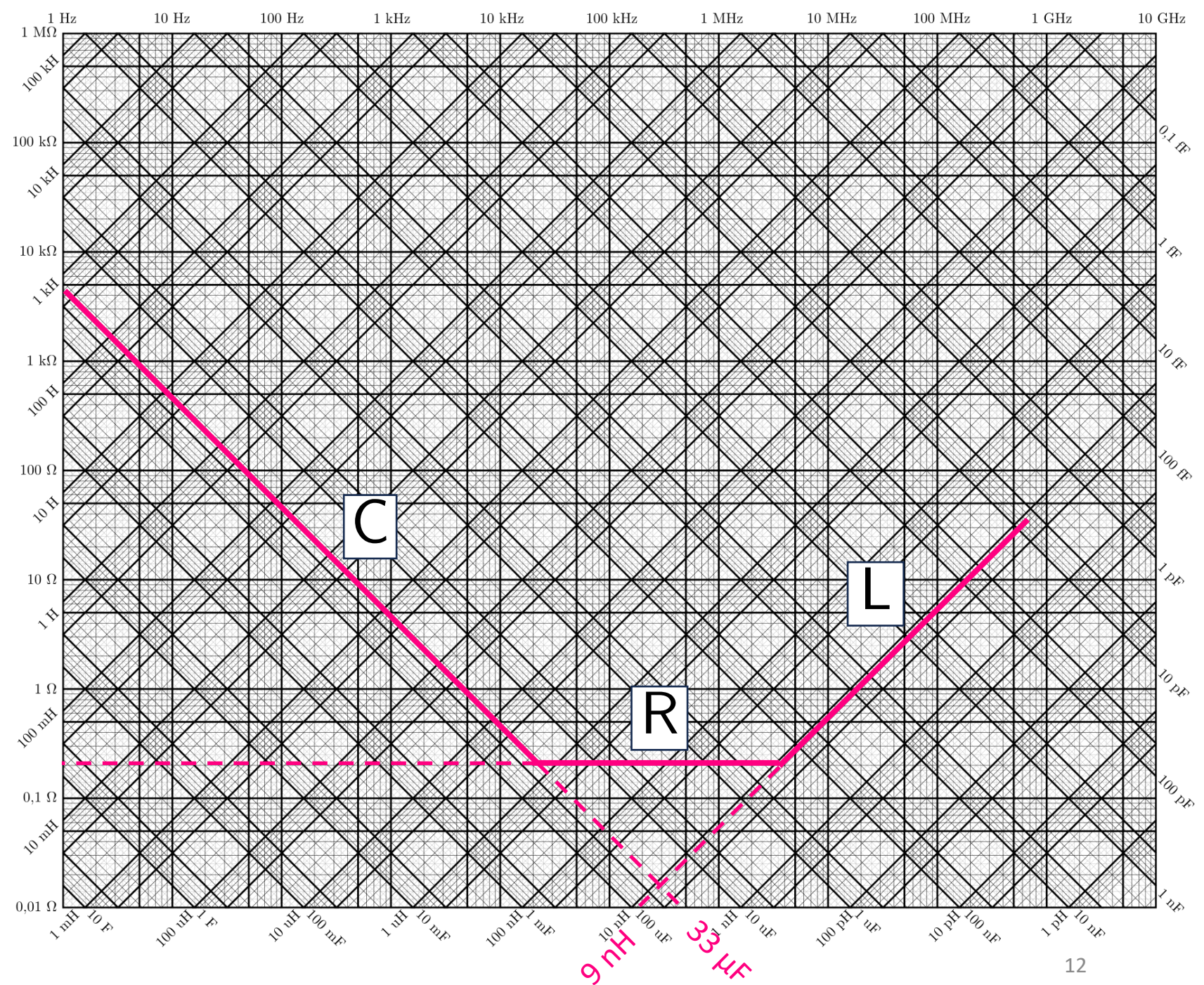
Impedanz



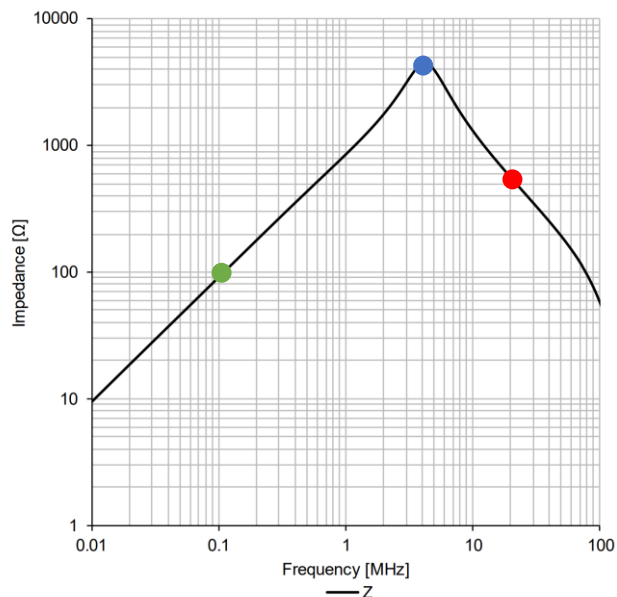
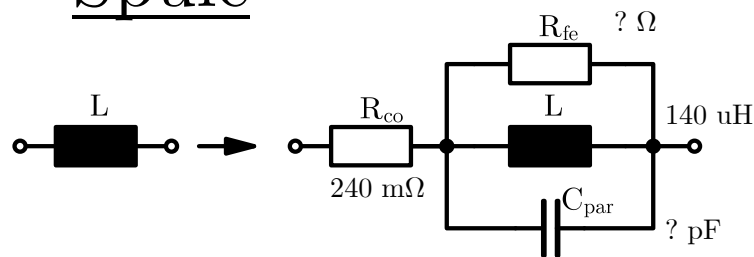
Elektrolyth Kondensator



[WELCA1]



Spule

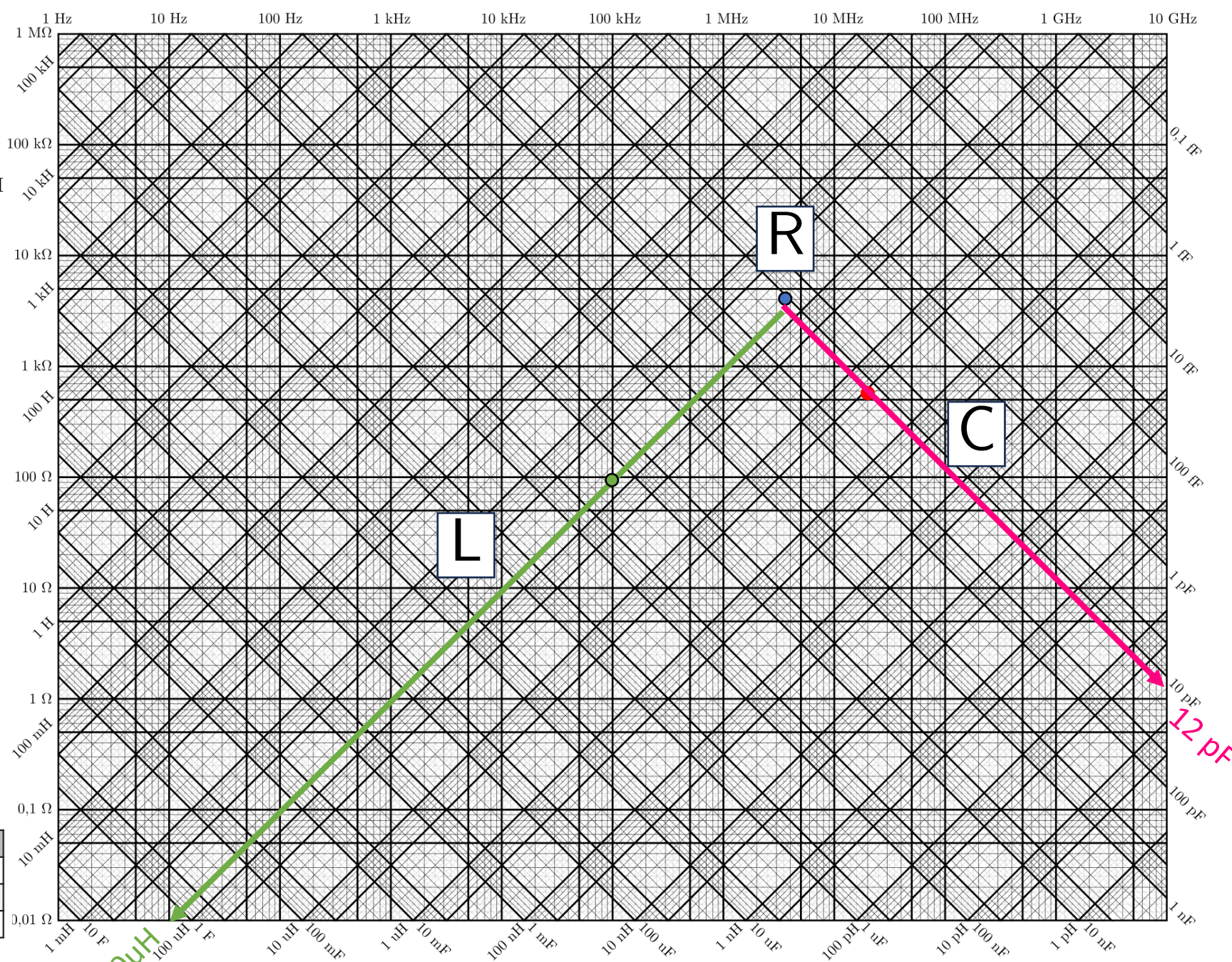


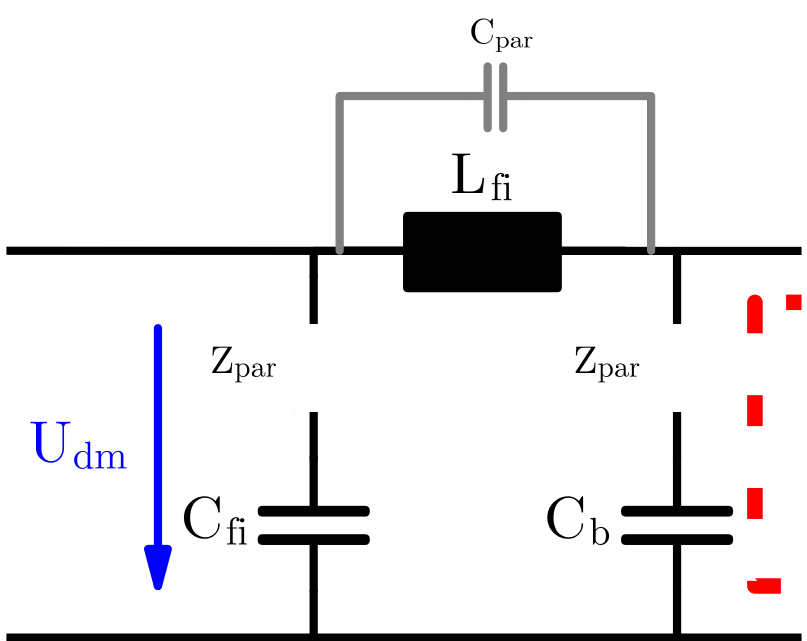
[WELIND]

[WELIND]

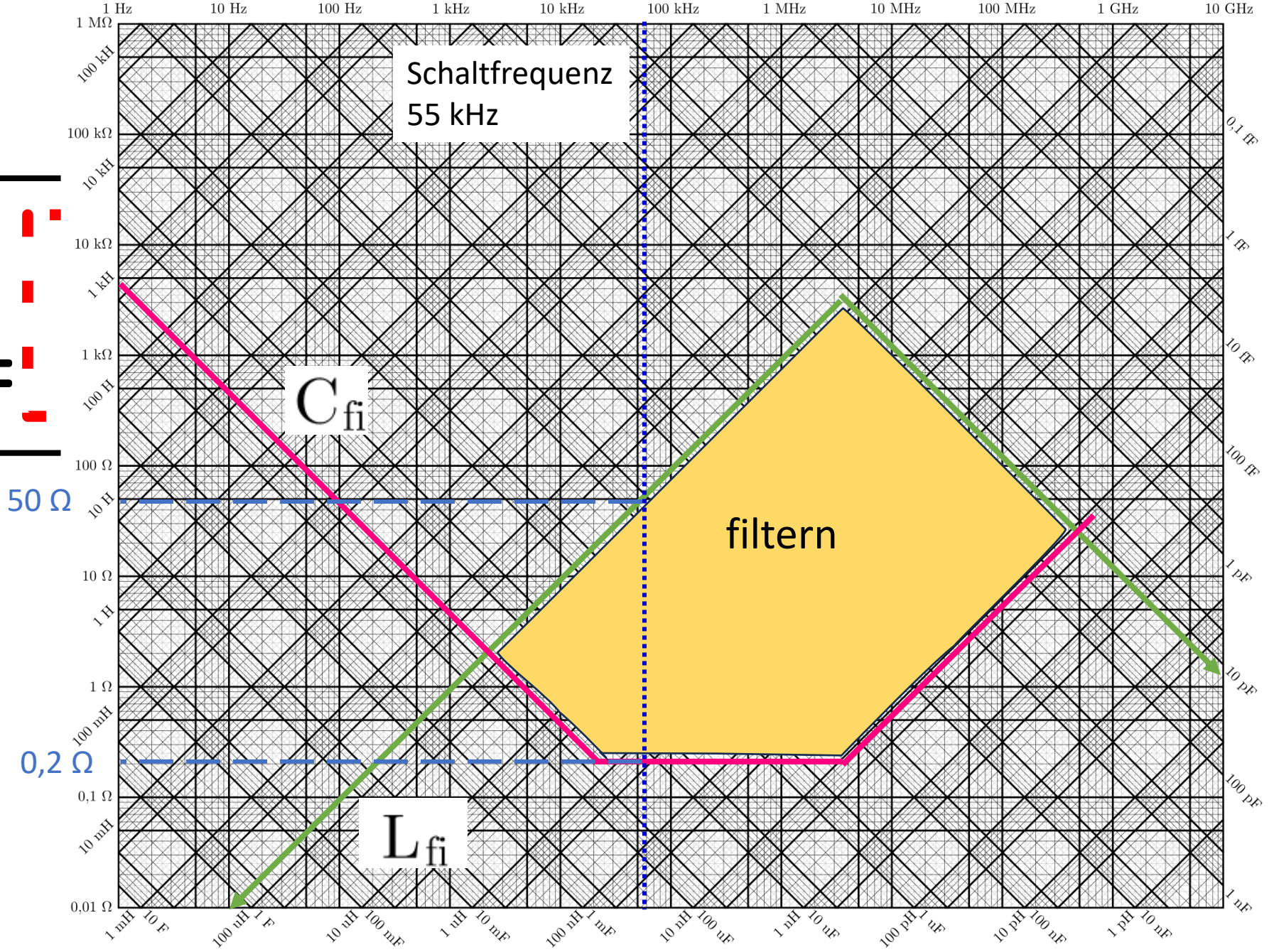
Electrical Properties:

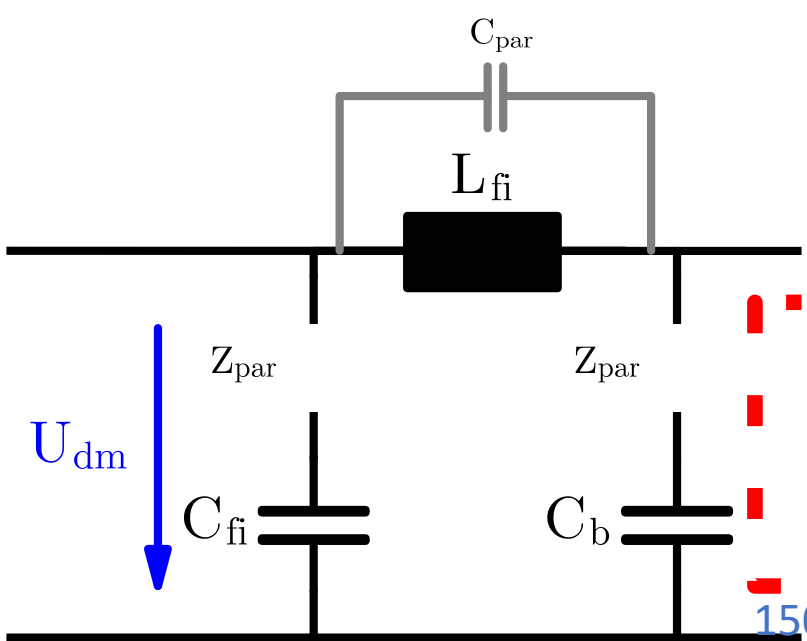
Properties		Test conditions	Value	Unit	Tol.
Inductance	L	10 kHz/ 5 mA	140	μH	±20%
Rated Current	I_R	$\Delta T = 40$ K	1.1	A	max.
DC Resistance	R_{DC}	@ 20 °C	0.26	Ω	max.



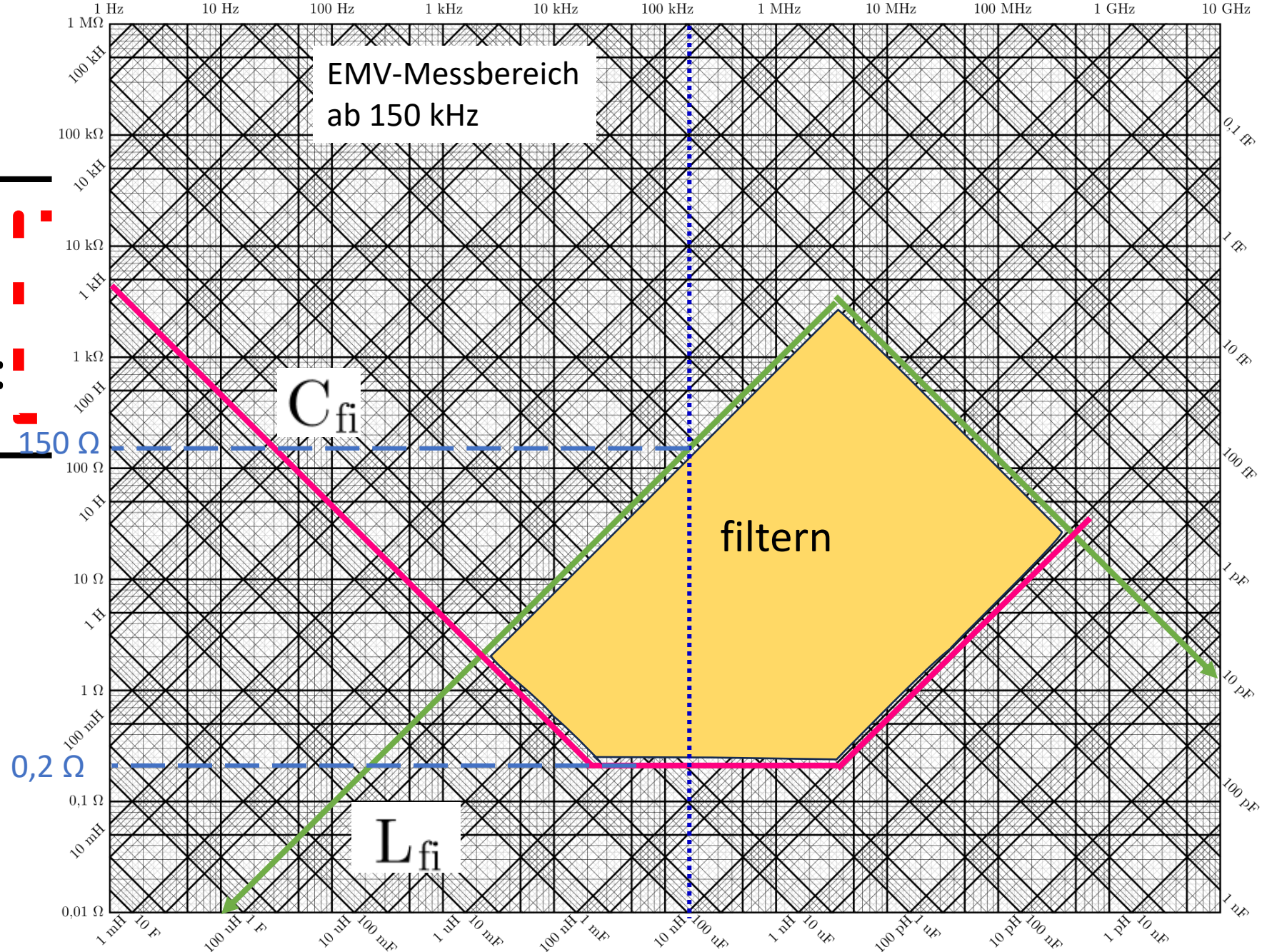


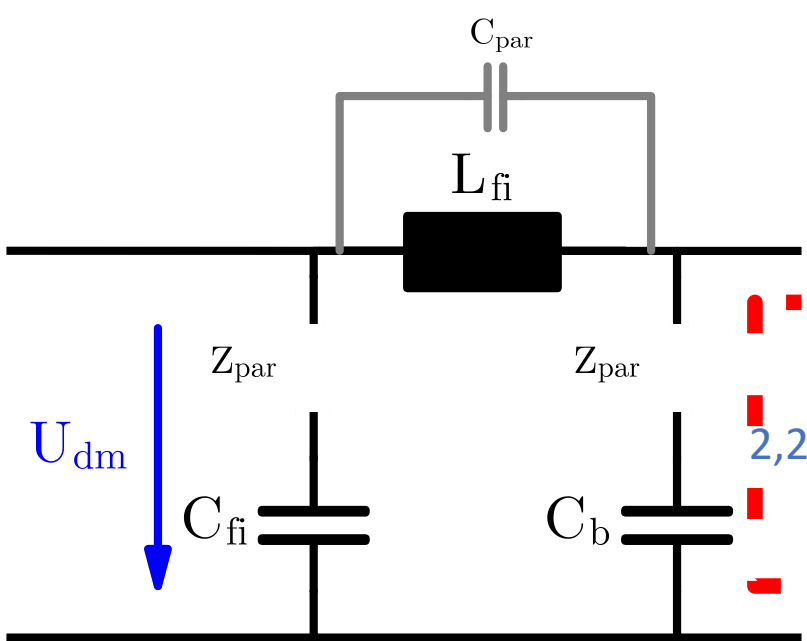
$$20 \cdot \log_{10} \frac{50}{0,2} \approx 48\ dB$$



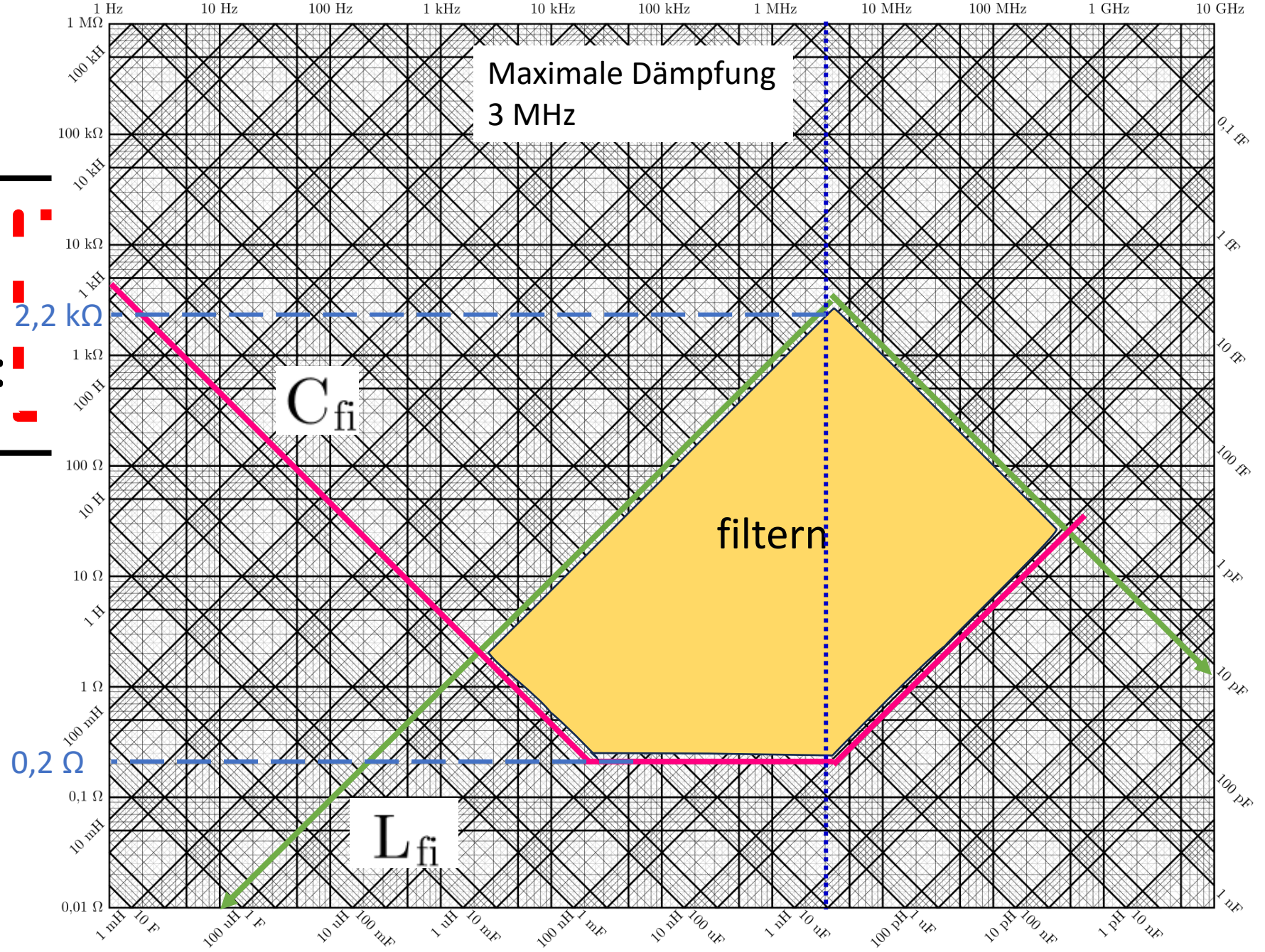


$$20 \cdot \log_{10} \frac{150}{0,2} \approx 58 \text{ dB}$$



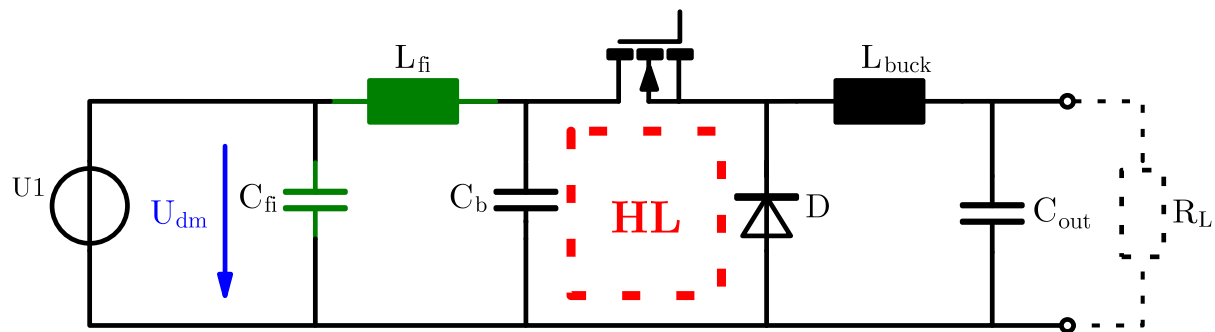
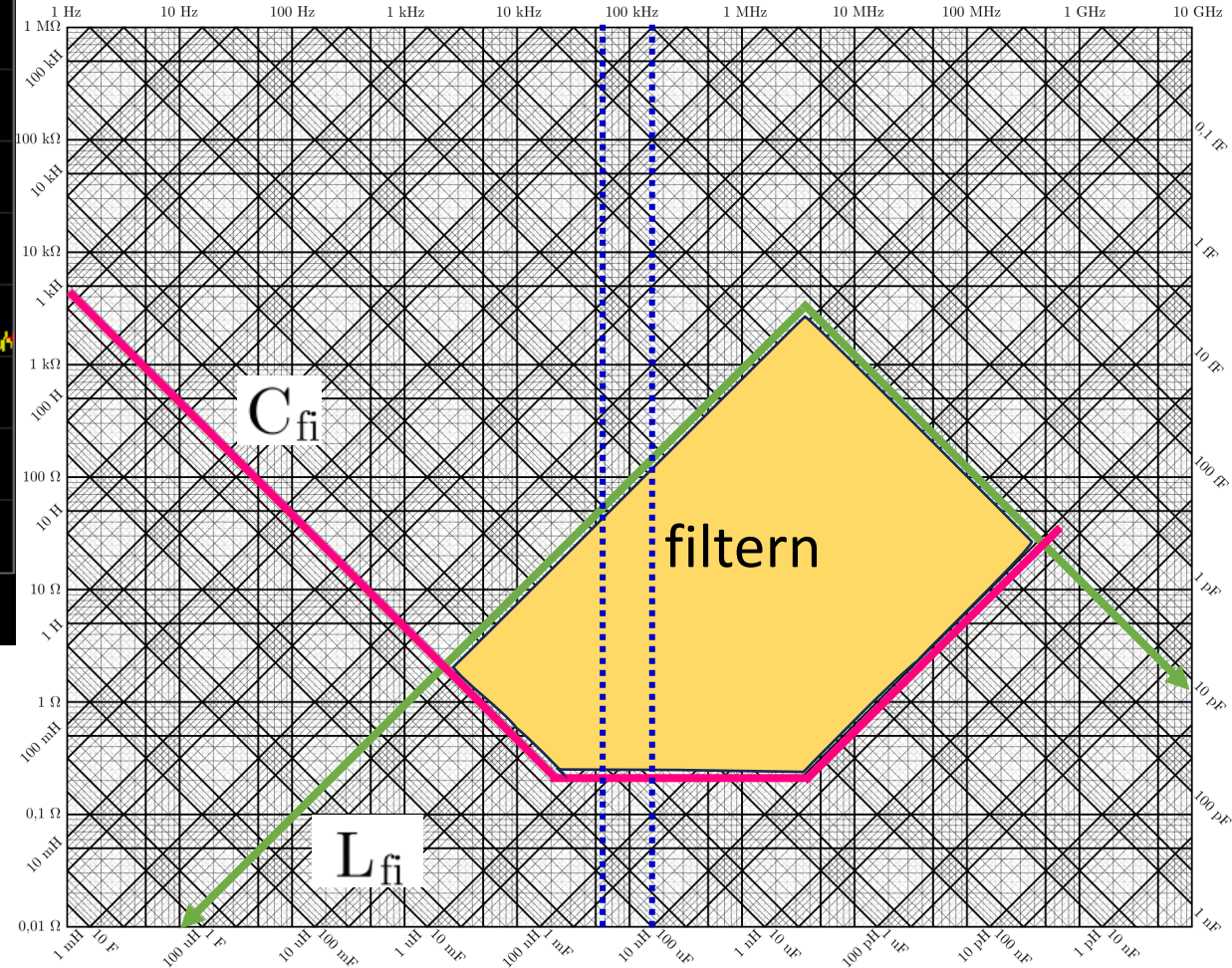


$$20 \cdot \log_{10} \frac{2200}{0,2} \approx 81 \text{ dB}$$

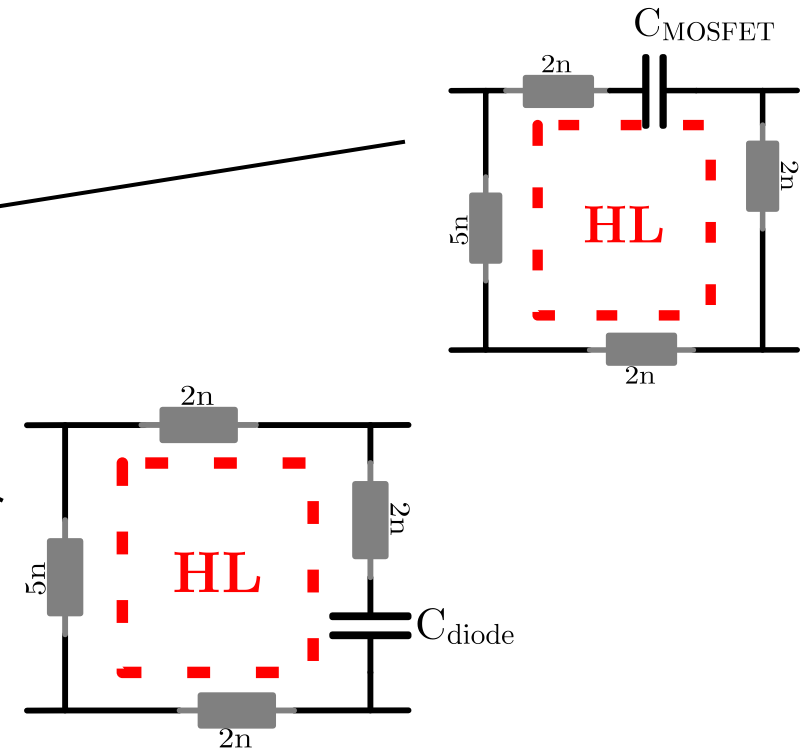
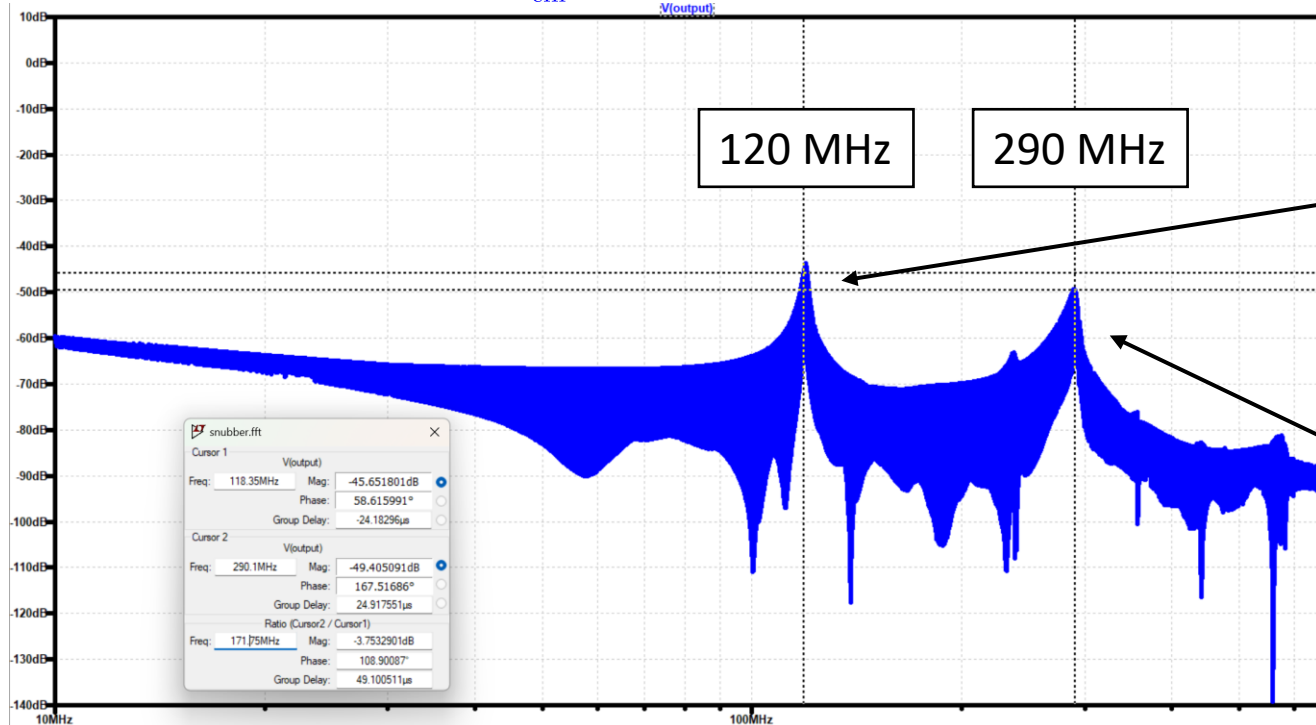
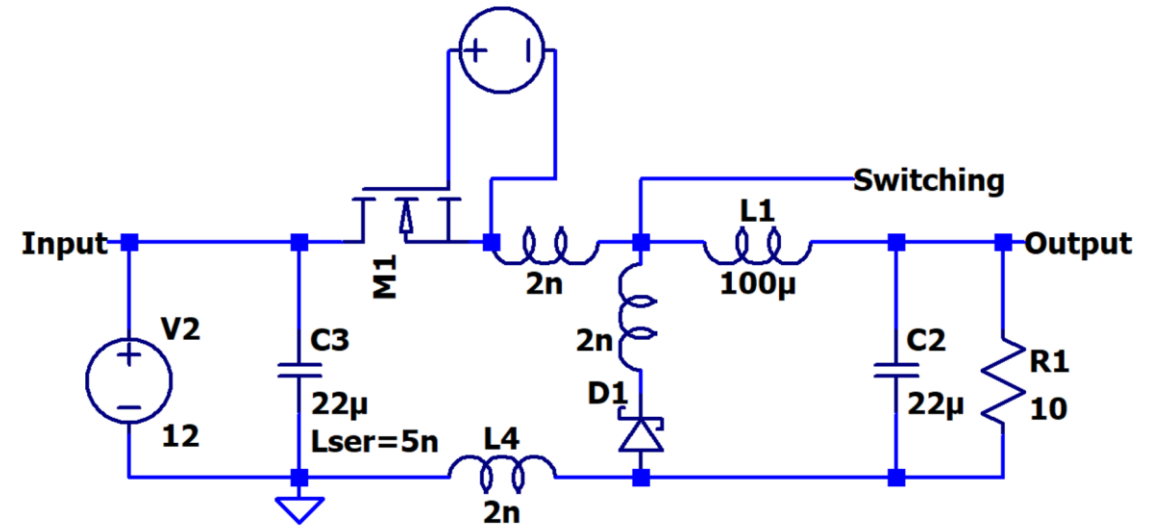
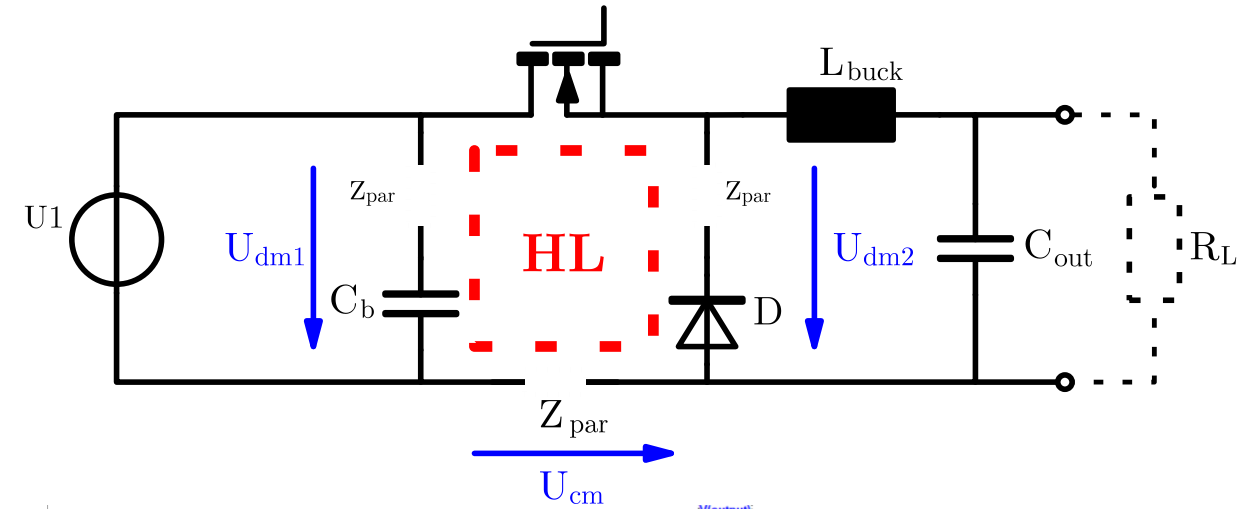


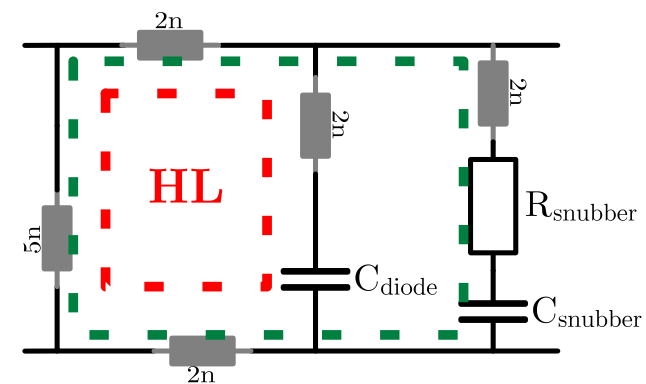
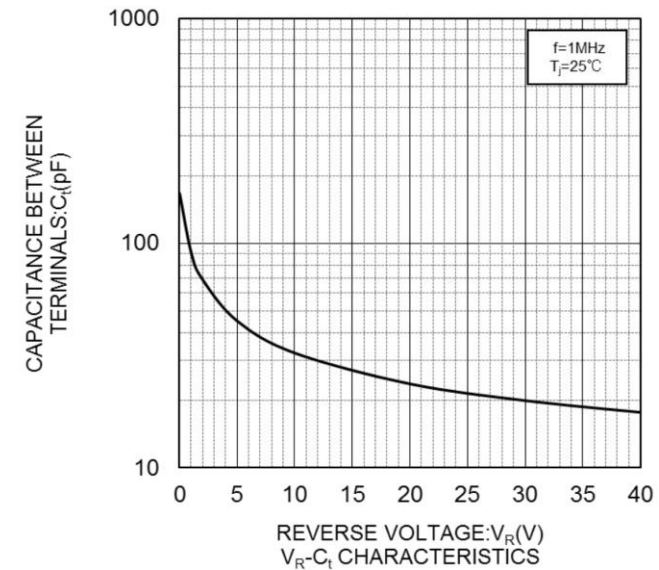
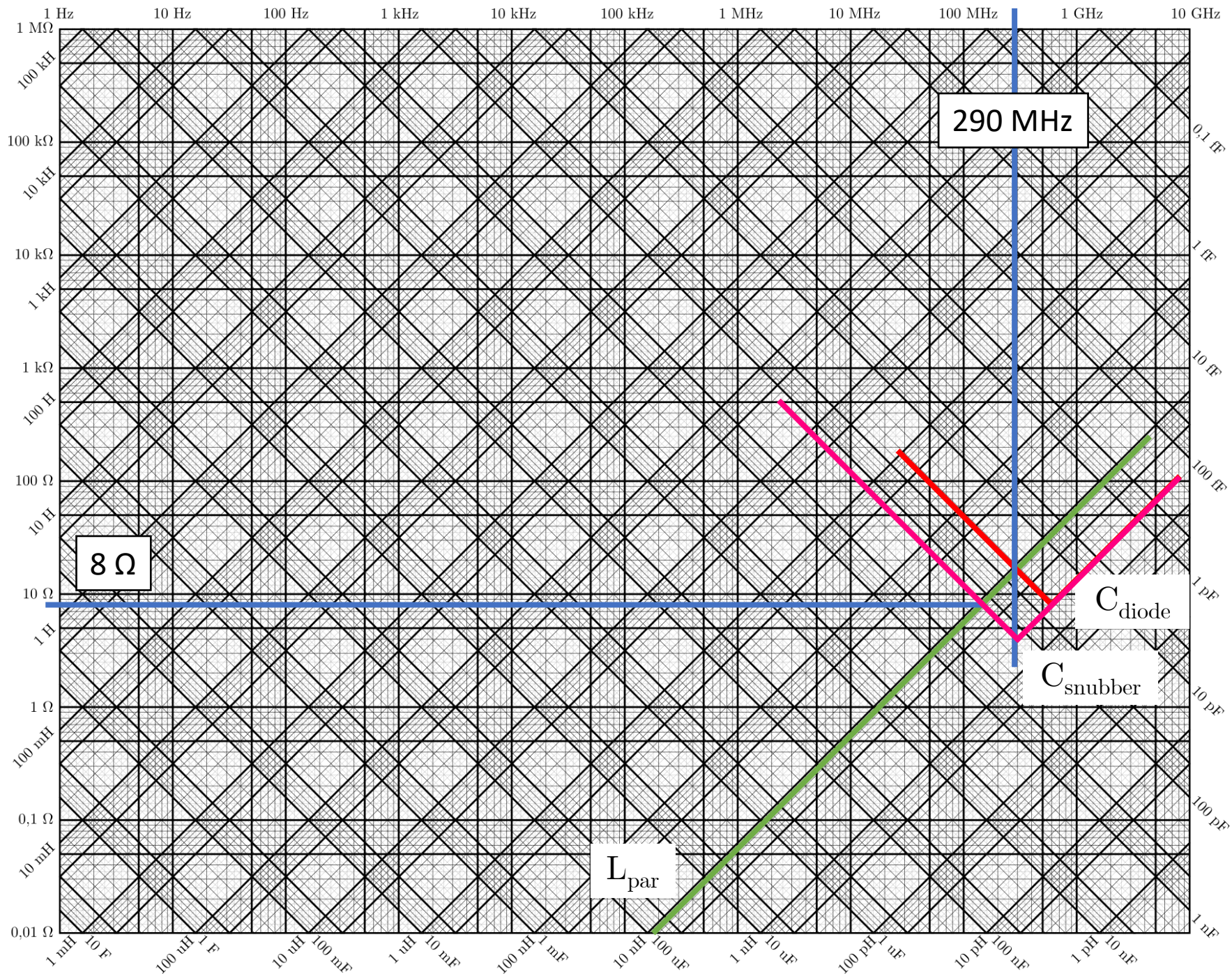


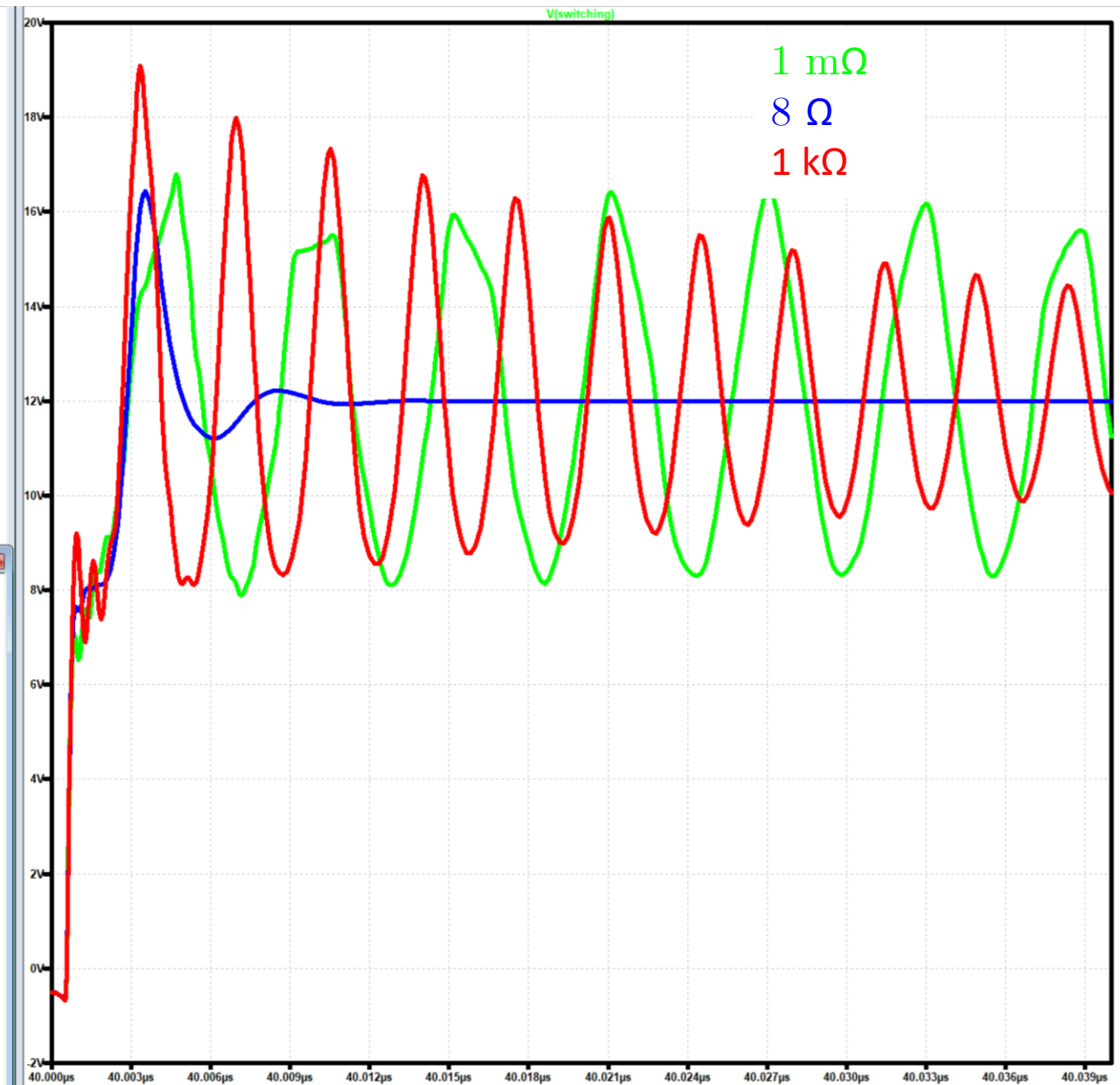
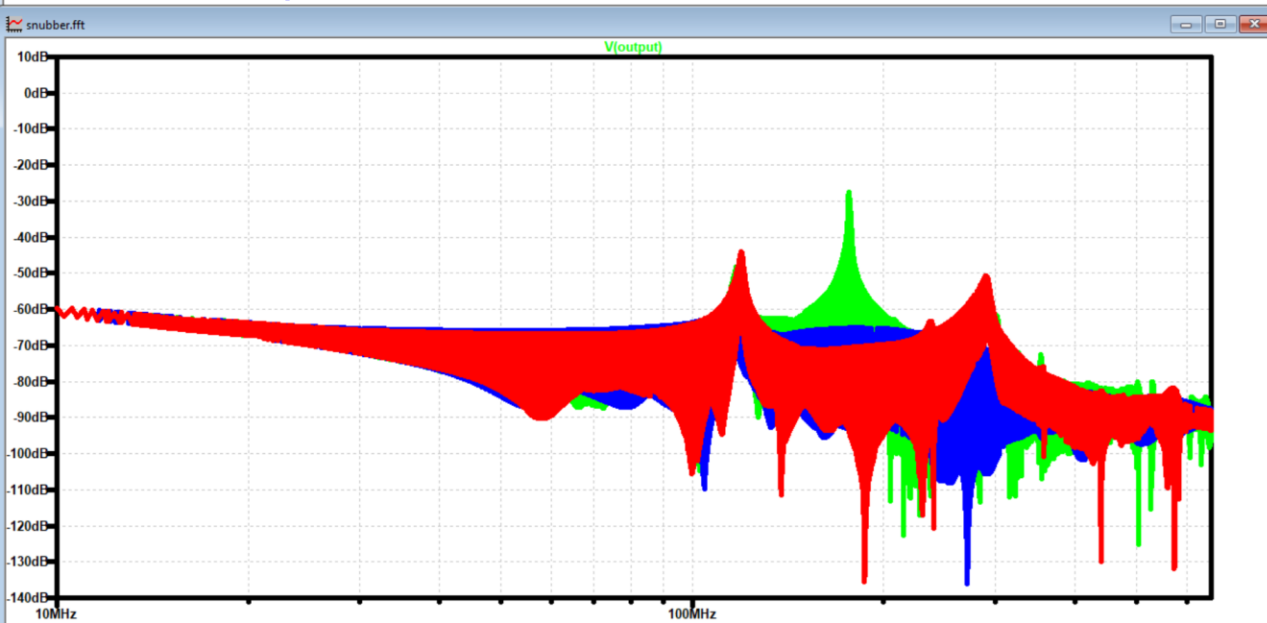
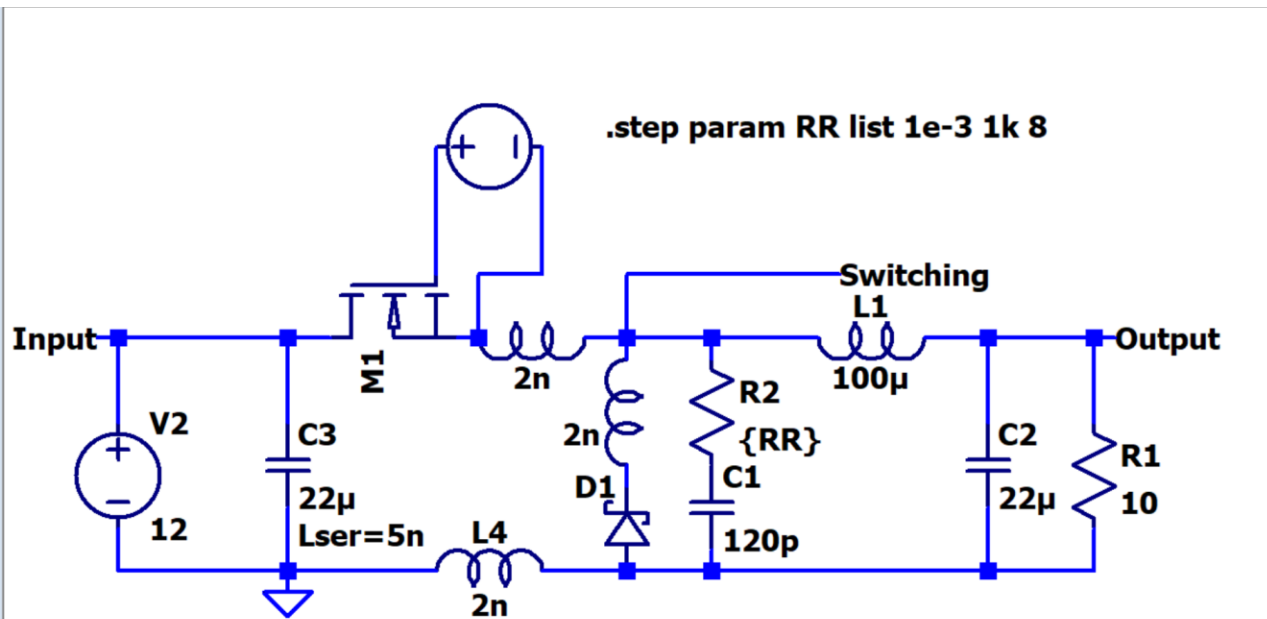
➔ Kosten senken durch Bauteilauswahl?



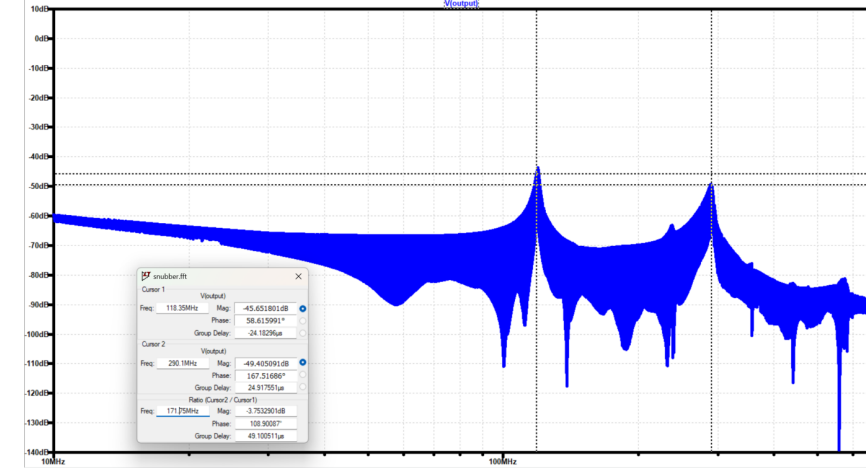
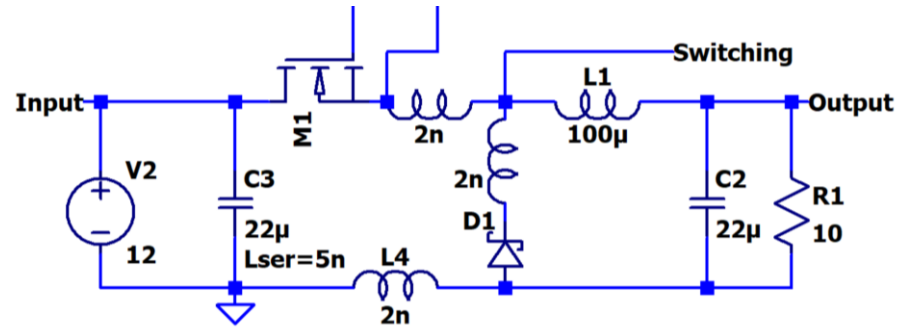
3. Snubber-Design



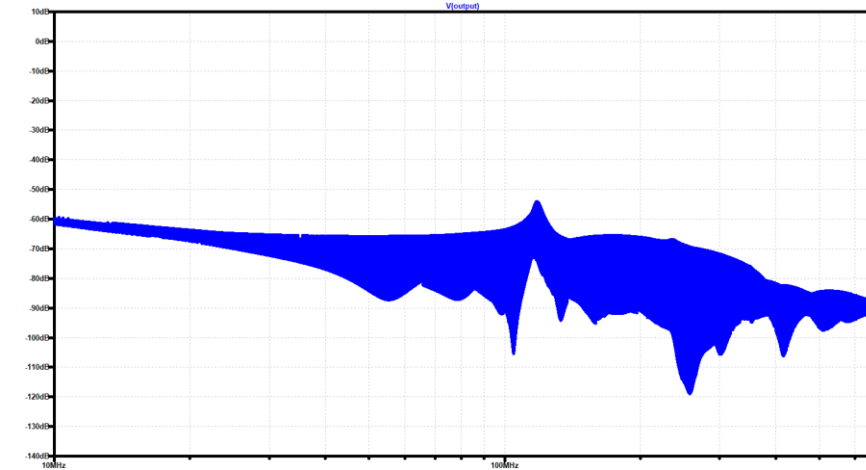
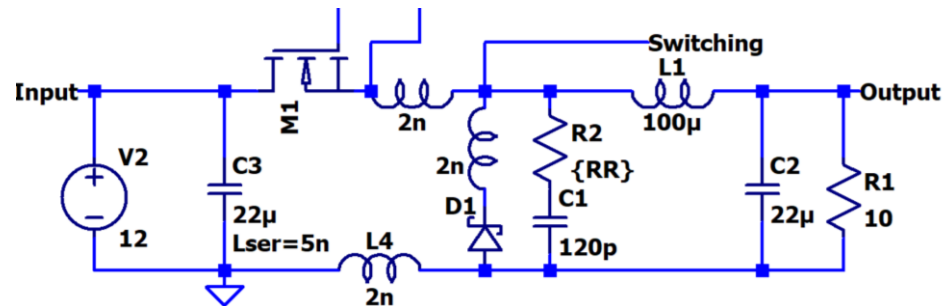




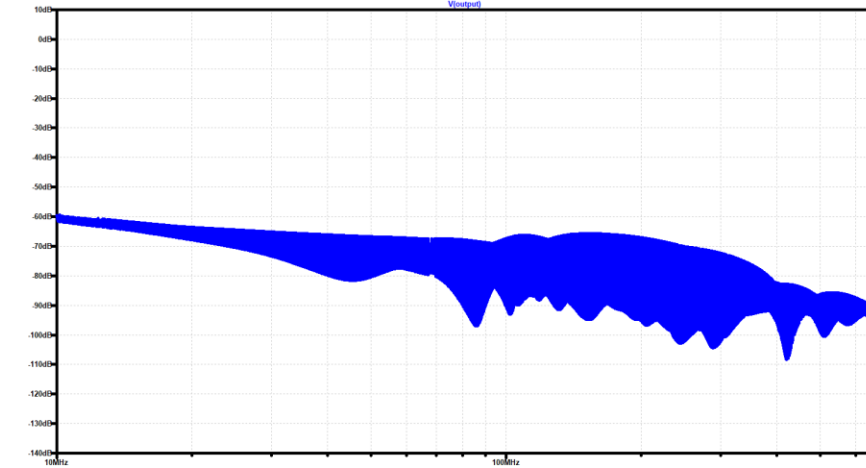
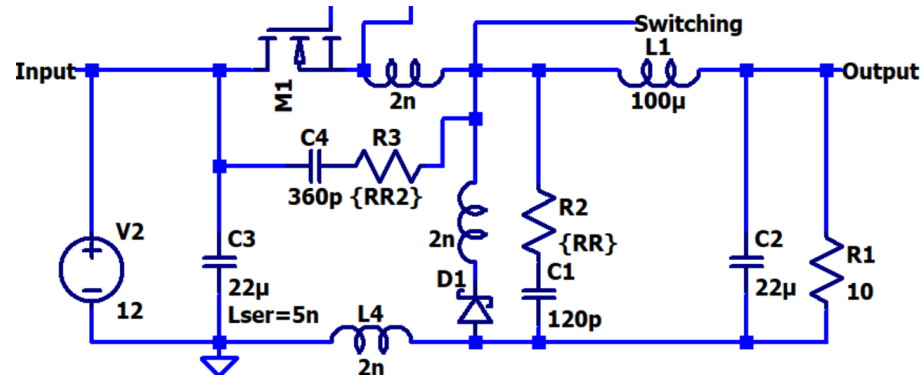
Kein Snubber



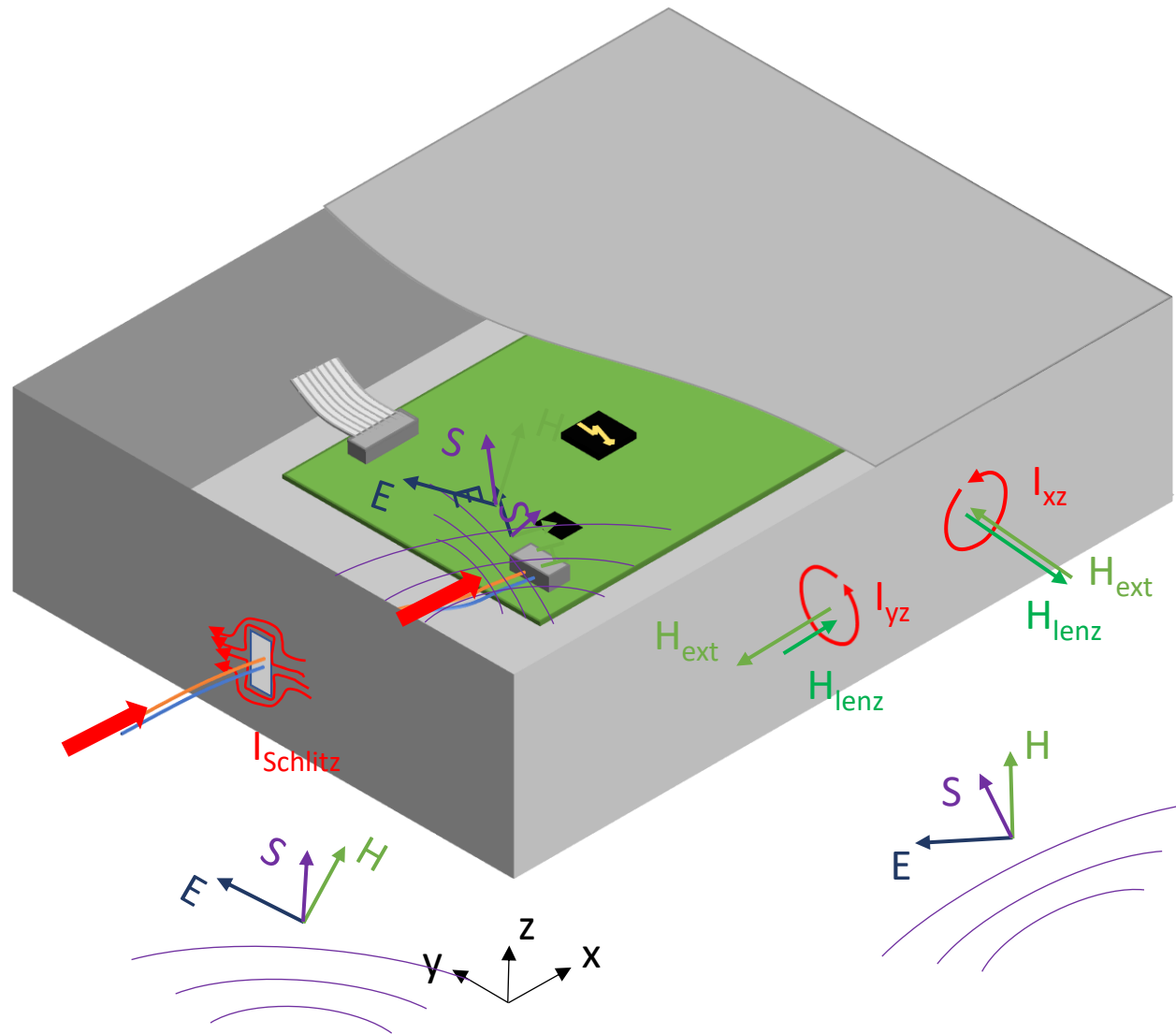
Ein Snubber



Zwei Snubber



4. Gehäuseschirmung



Niederfrequent elektrisch

→ Faraday'scher Käfig

Hochfrequent elektrisch

→ Geschlossene leitfähige Schirmung

Stromdichte:

$$J(x) = -\frac{dH(x)}{dx}$$

$$|J(x)| = |J(0)| \cdot e^{-\frac{x}{\delta}}$$

Skin-Tiefe:

$$\delta = \sqrt{\frac{1}{\pi f \kappa \mu}}$$

Kupfer:

$\delta \approx 1\text{mm}$ @ 5 kHz

$\delta \approx 0,1\text{mm}$ @ 0,5 MHz

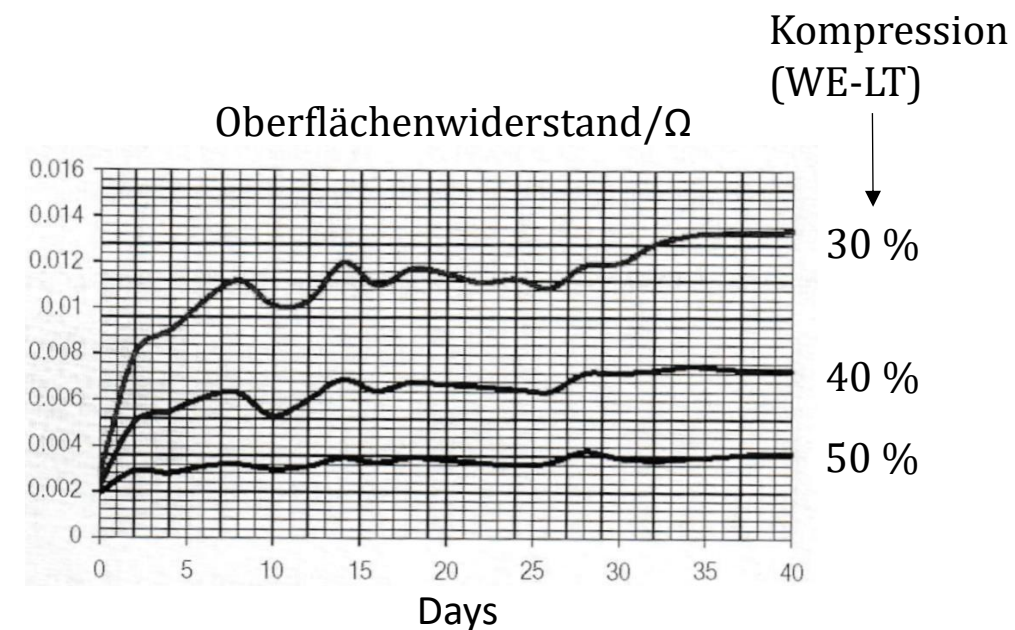
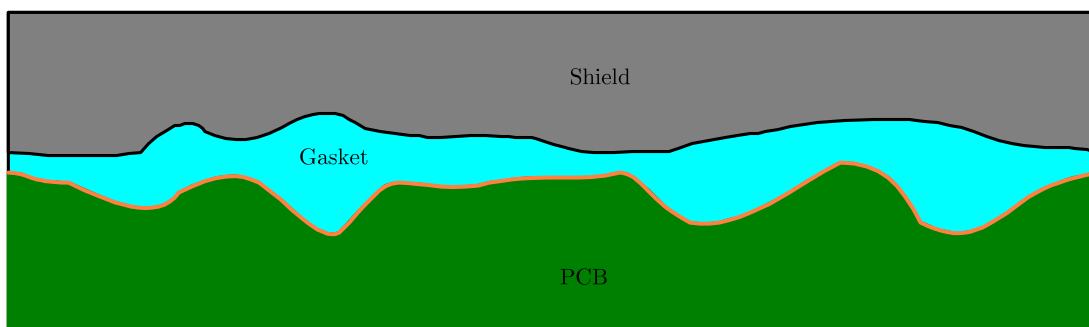
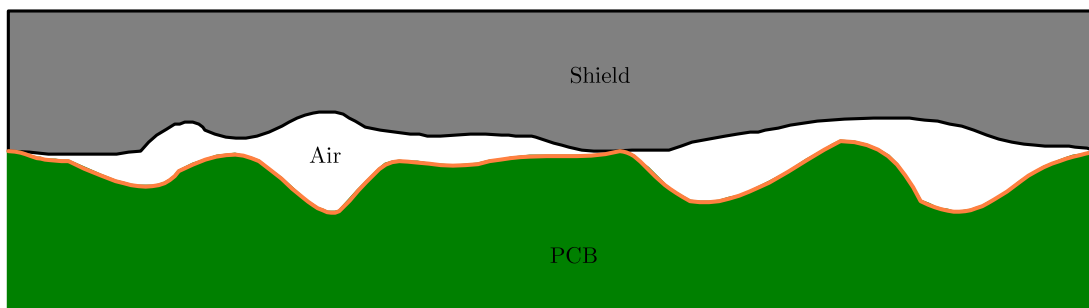
$\delta \approx 0,01\text{mm}$ @ 50 MHz

Niederfrequent magnetisch

→ mit Mumetal umschließen, um Feldlinien umzuleiten

Hochfrequent magnetisch

→ Geschlossene leitfähige Schirmung

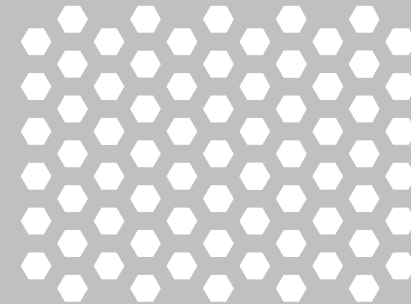


[WELTRIL]

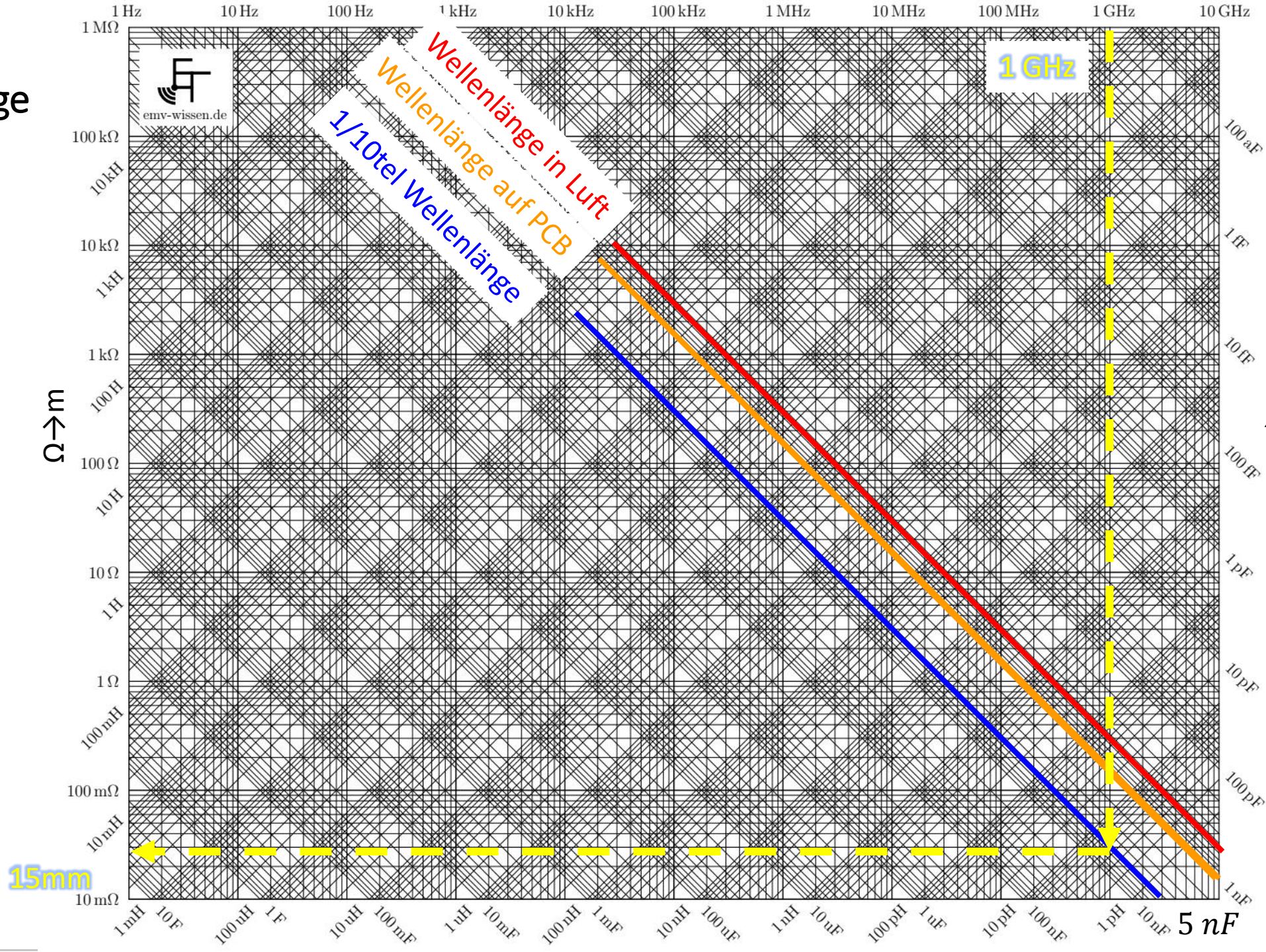
Kombinationen von Materialien (WE-LT)

+	Aluminium
+	Eisen, Gold
++	Silber
-	Stahl galvanisiert
++	Zinn
--	Magnesiumlegierung
++	Kupfer

Lüftung



Schlitzlänge



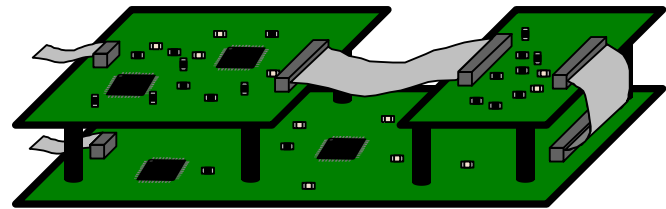
$$\lambda = \frac{c}{f}$$

$$\lambda/m \approx \frac{300}{f/MHz}$$

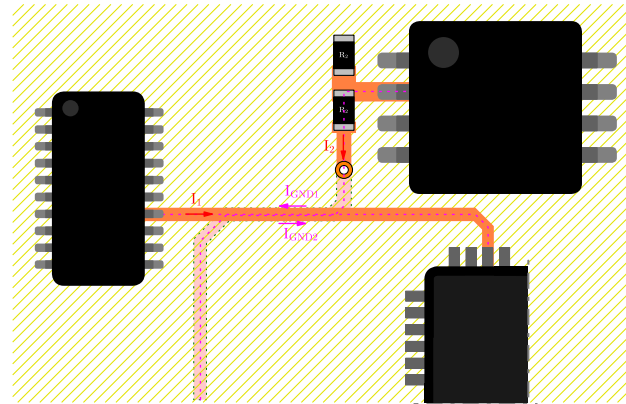
EMV/HF Workshop in Regensburg 5.-8.11.2024 (Anmeldung beendet)

Für nächstes Jahr bereits anfragen und Frühbucherrabatt sichern.

Tag 1: EMV auf Geräteebe

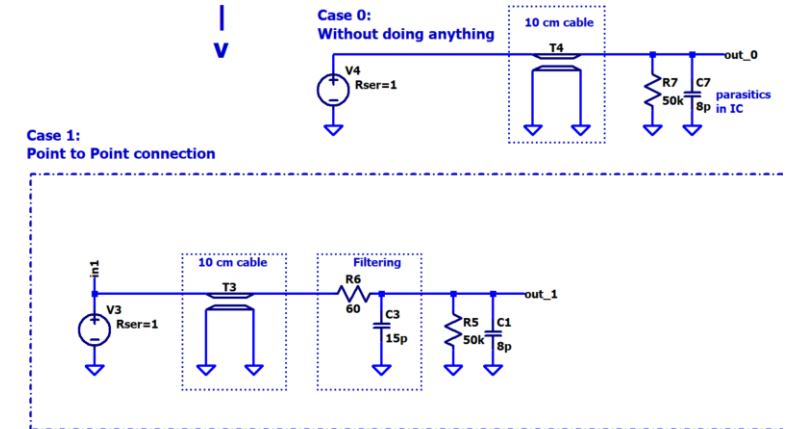


Tag 2: EMV auf Leiterplatte



Tag 3: EMV-Entwicklung

Termination at sink



Tag 4: Hochfrequenztechnik

